

Class 11

Van der Waals Materials

28.04.2025

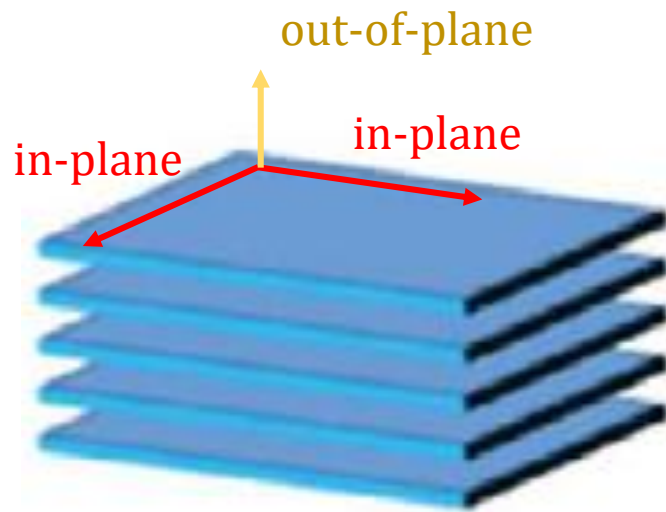
- ☐ Layered crystals
 - Crystal structure
 - Layer dependent band structure
 - Spin-valley locking
- ☐ Effect of stacking order
 - Parallel configuration
 - Antiparallel configuration
 - Twisted layers
- ☐ Doping strategies

VdW Materials = 2D Crystals

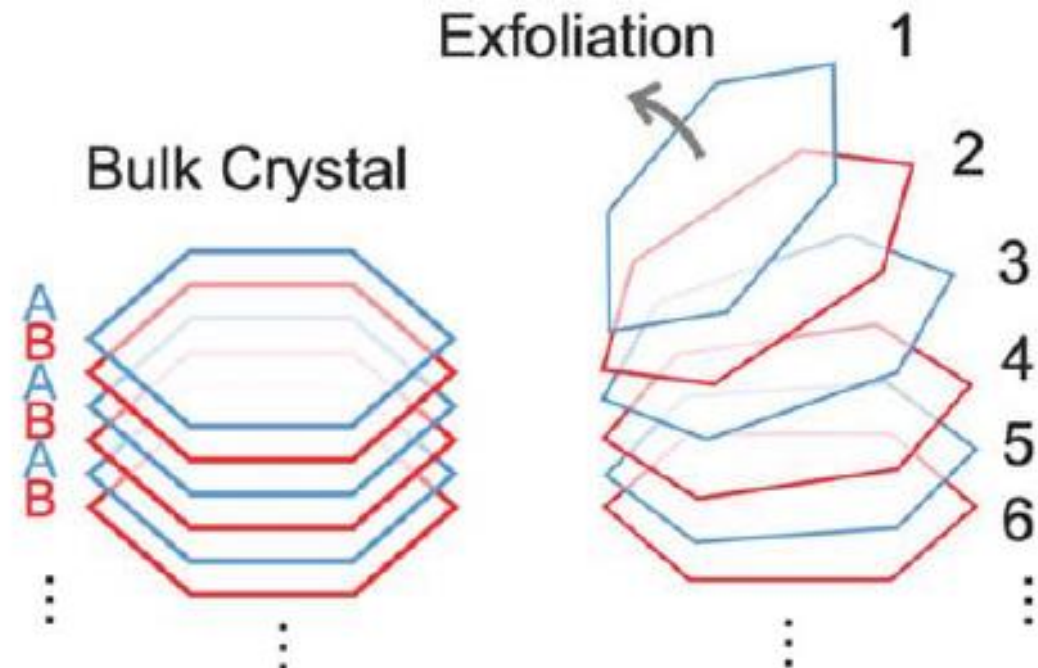
DEFINITION:

[...] layered materials with strong in-plane bonds
and weak, van der Waals-like coupling between layers.

Novoselov et al. PNAS, 102, 30 (2005)



Yao, J.D. et al., Prog.Mat.Sc., 106 (2019)



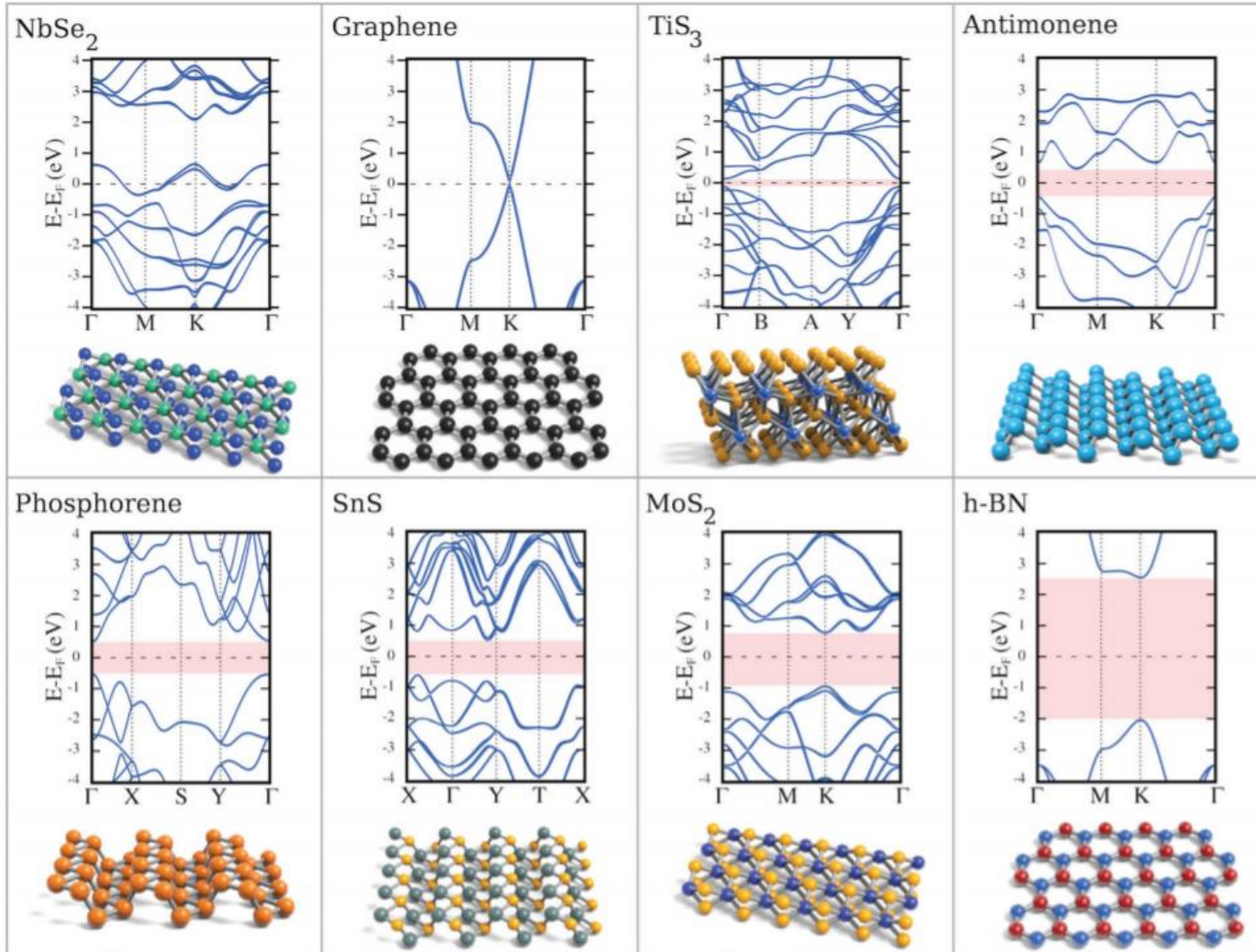
F.Liu et al. Science, 367 (2020)

VdW Materials = 2D Crystals

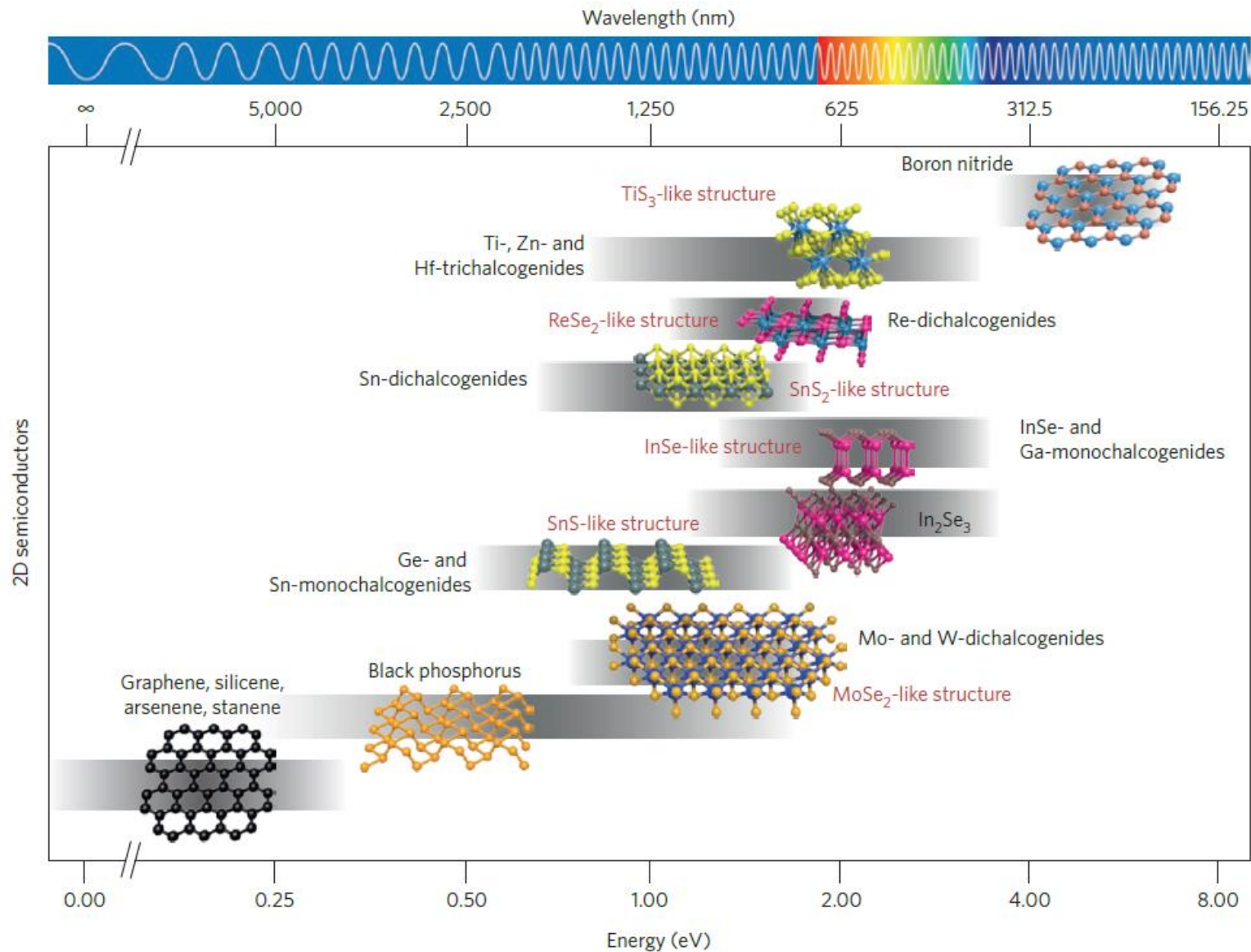
DEFINITION:

Dimensionality is one of the most defining material parameters; the same chemical compound can exhibit dramatically different properties depending on whether it is arranged in a 0D, 1D, 2D, or 3D crystal structure. Although quasi-0D [e.g., cage molecules (**1**)], quasi-1D [e.g., nanotubes (**2-4**)], and, of course, 3D crystalline objects are well documented, dimensionality two is conspicuously absent among experimentally known crystals. On the other hand, there are many layered materials with strong in-plane bonds and weak, van der Waals-like coupling between layers. Because of this layered structure, it has long been tempting to try splitting such materials into individual atomic layers, although it remained unclear whether free-standing atomic layers could exist in principle [thin films become thermodynamically unstable (decompose or segregate) below a certain thickness, typically, of many dozens layers].

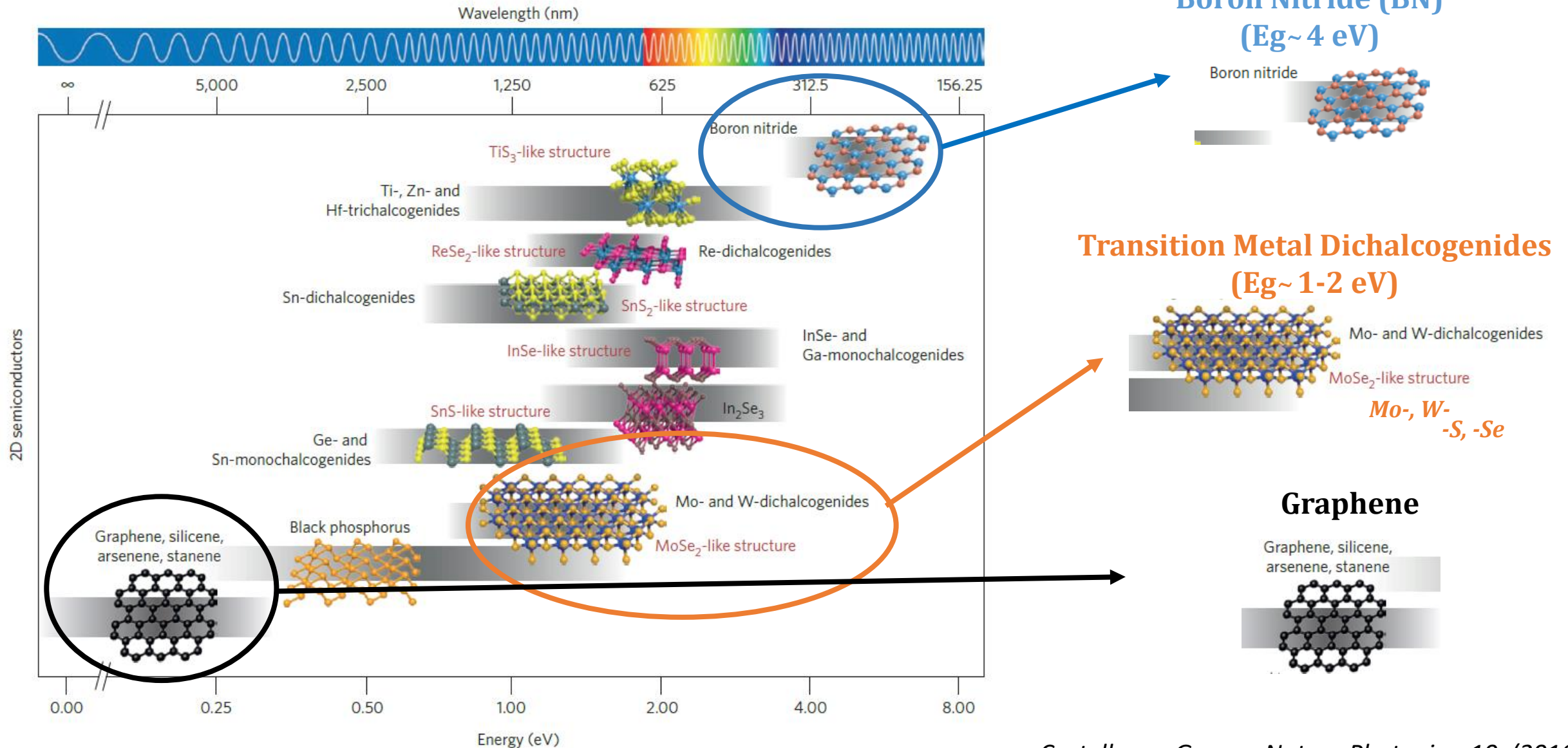
Van der Waals Compounds



Van der Waals Compounds

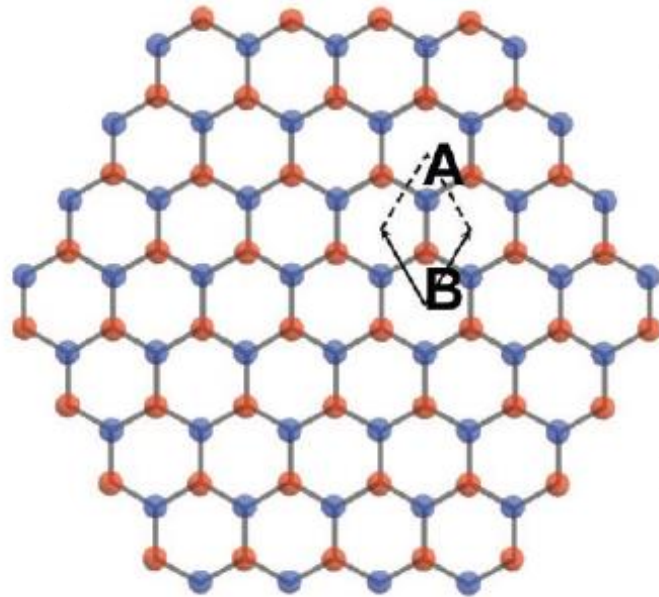


Van der Waals Compounds



Crystal structure (1)

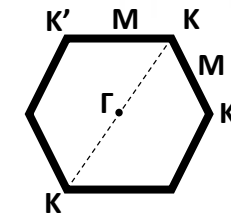
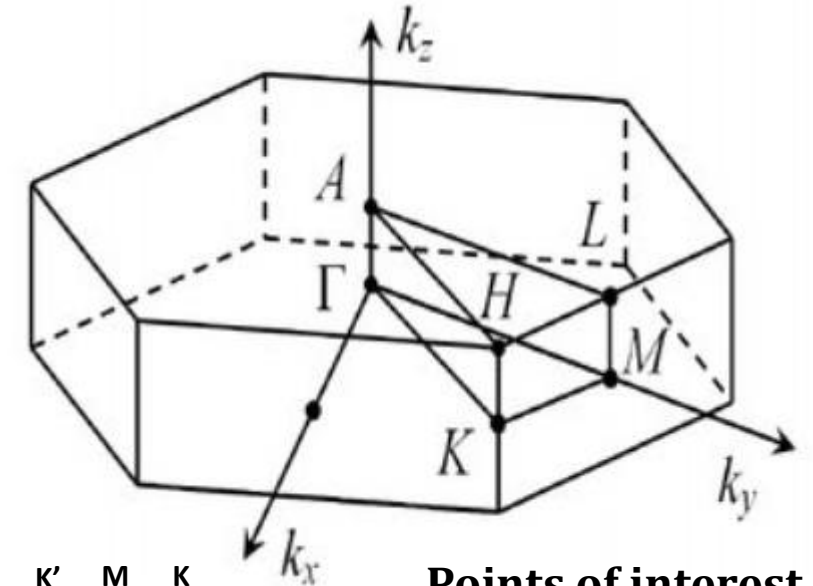
Planar atomic layer = sp^2 hybridization = **hexagonal lattice**



Graphene
(atomic compound)

BN*
(bi-atomic compound)

Brillouin Zone



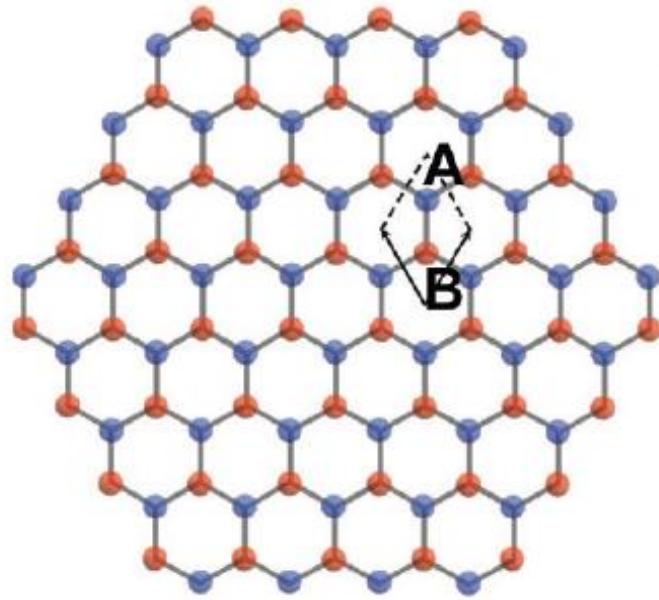
Points of interest

Γ = center of the BZ
K = Vertex
M = Middle of the edge
K' = asymmetric vertex

* Additional 3D phases exist, such as cubic BN (sp^3 hybridization).
To differentiate the phases, the 2D crystal is often named «h-BN»

Crystal structure (1)

Planar atomic layer = sp^2 hybridization = **hexagonal lattice**



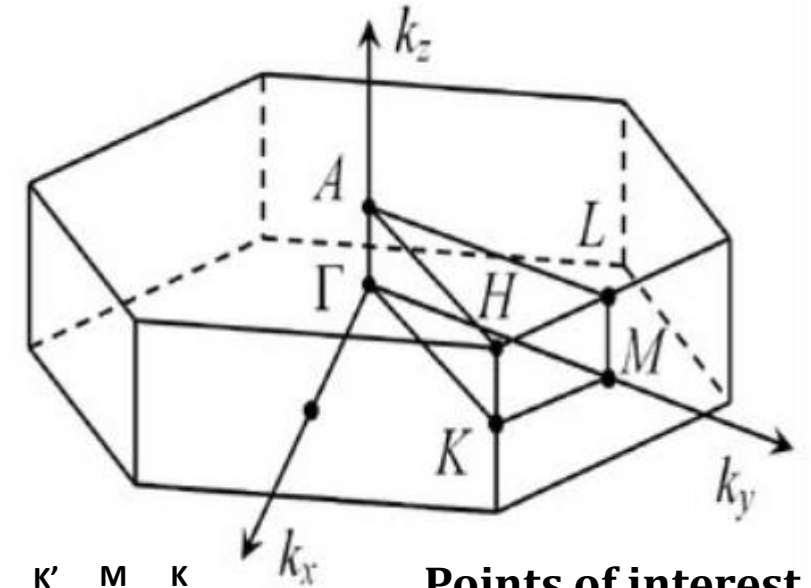
Graphene
(atomic compound)

BN*
(bi-atomic compound)

Which of these
compounds
present a K'
point in its BZ?

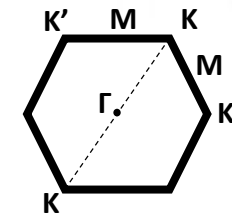
Avouris, NanoLetter, 10, (2010)

Brillouin Zone



Points of interest

Γ = center of the BZ
 K = Vertex
 M = Middle of the edge
 K' = asymmetric vertex



* Additional 3D phases exist, such as cubic BN (sp^3 hybridization).
To differentiate the phases, the 2D crystal is often named «h-BN»

Crystal structure (2)

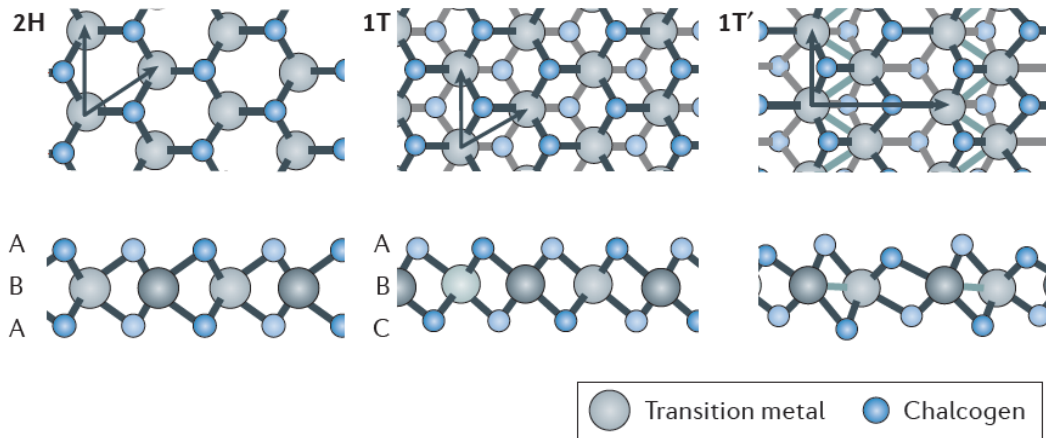
Transition Metal Dichalcogenides (TMDs)

Formula: MX_2

M = Metal (W, Mo, Nb, Ti...)

X = Chalcogen (S, Se or Te)

Lattice depends on the coordination of the metal atom.



Trigonal prismatic

Octahedral

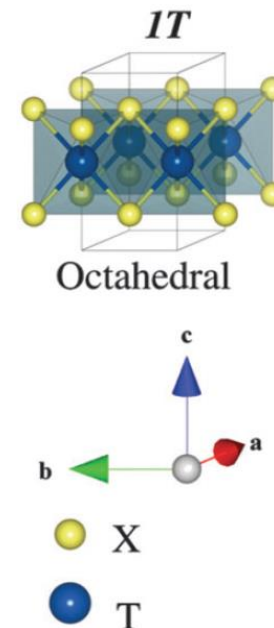
Dimerized

1T, 2H, 3R

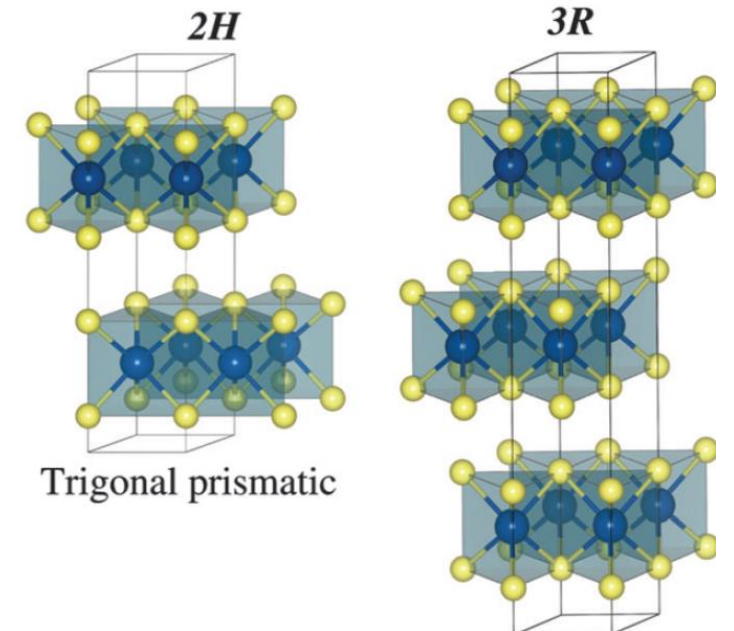
Number of layers in the unit

+

Letter denotes the symmetry



(Hexagonal Lattice)

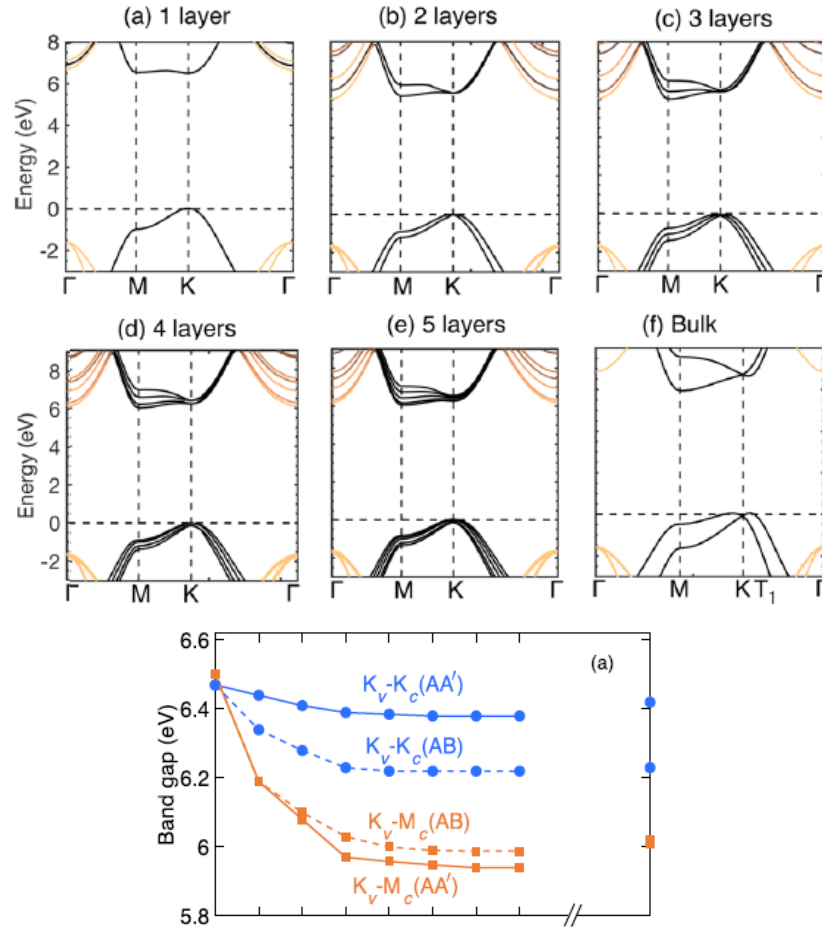


Thermodynamically Stable Phases for:

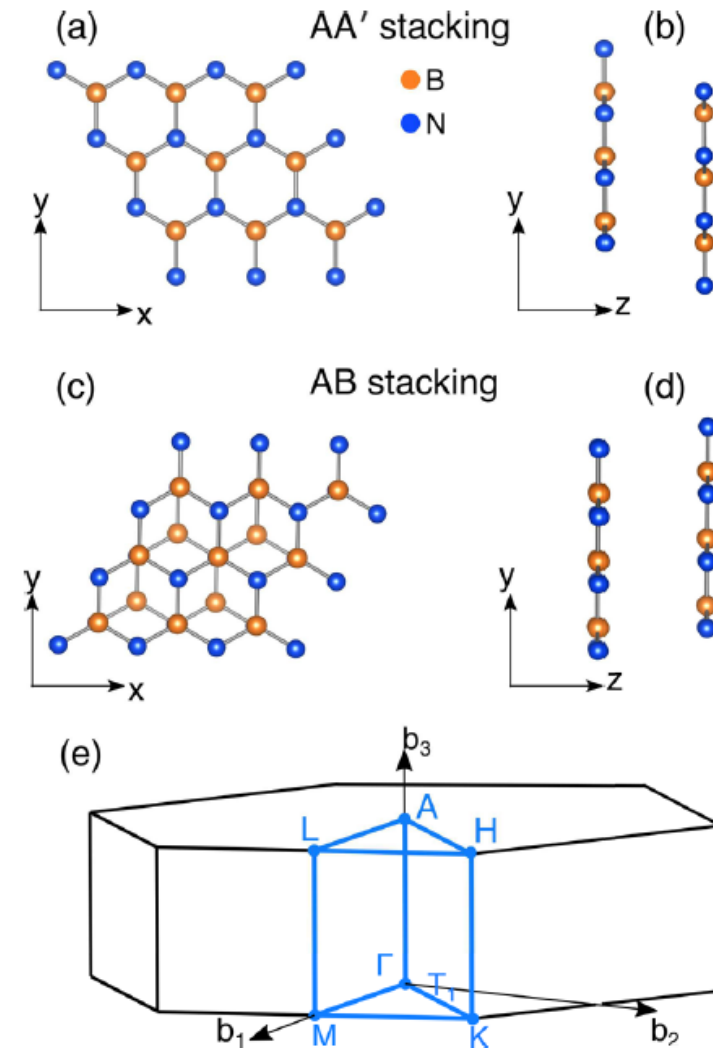
MoS ₂	WS ₂
MoSe ₂	WSe ₂

Unique Features

Layer-dependance

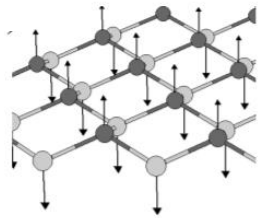


Sequencing

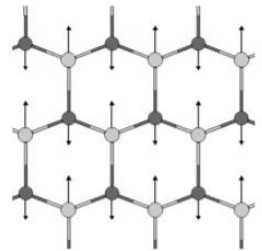


Bulk to monolayer: lattice vibration

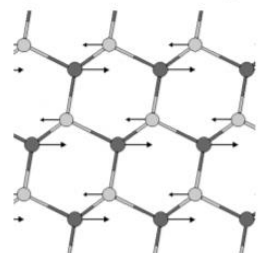
Example of vibrational modes (h-BN)



Out-of-plane

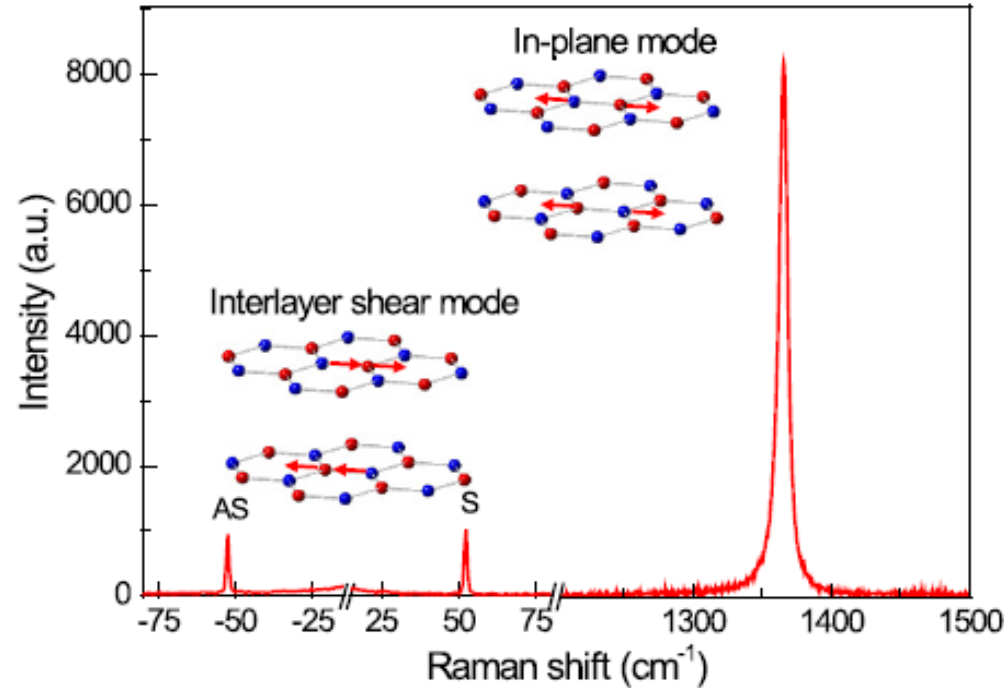


In-plane
(Transverse)



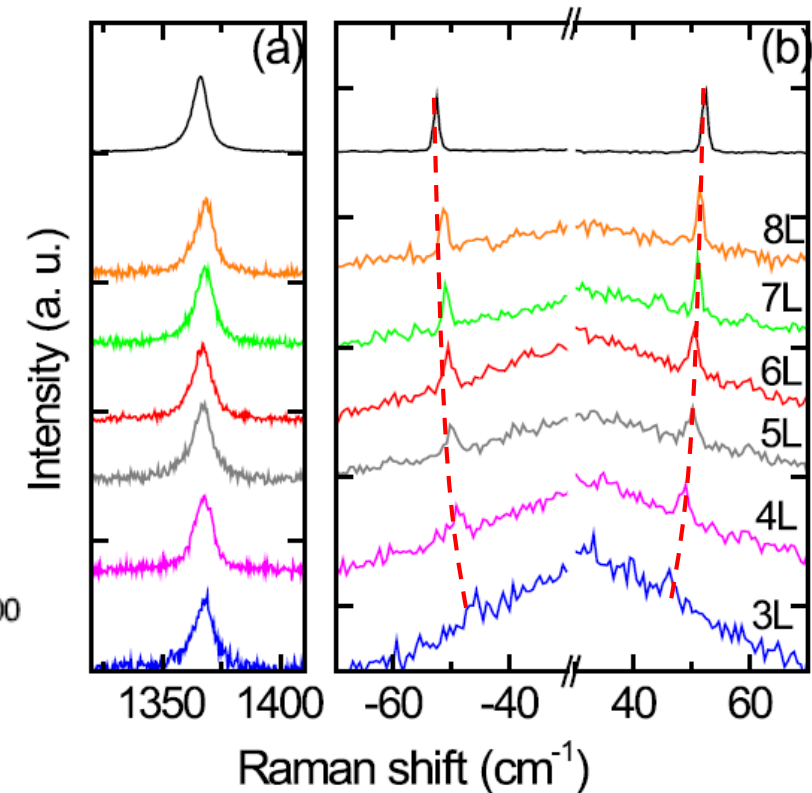
In-plane
(Longitudinal)

Bulk h-BN



No significant variation on in-plane mode Raman peak at $\sim 1350 \text{ cm}^{-1}$

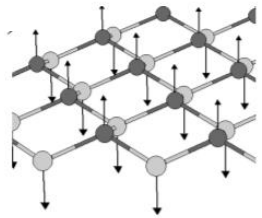
Decreasing number of layers (L)



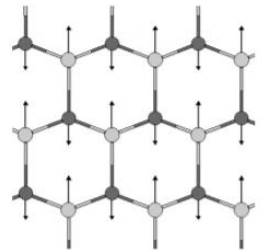
Significant shift of the shear mode Raman peak at $\sim 50 \text{ cm}^{-1}$

Bulk to monolayer: lattice vibration

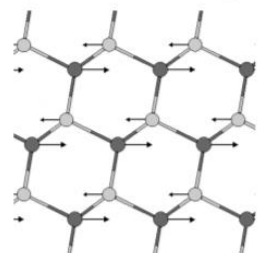
Example of vibrational modes (h-BN)



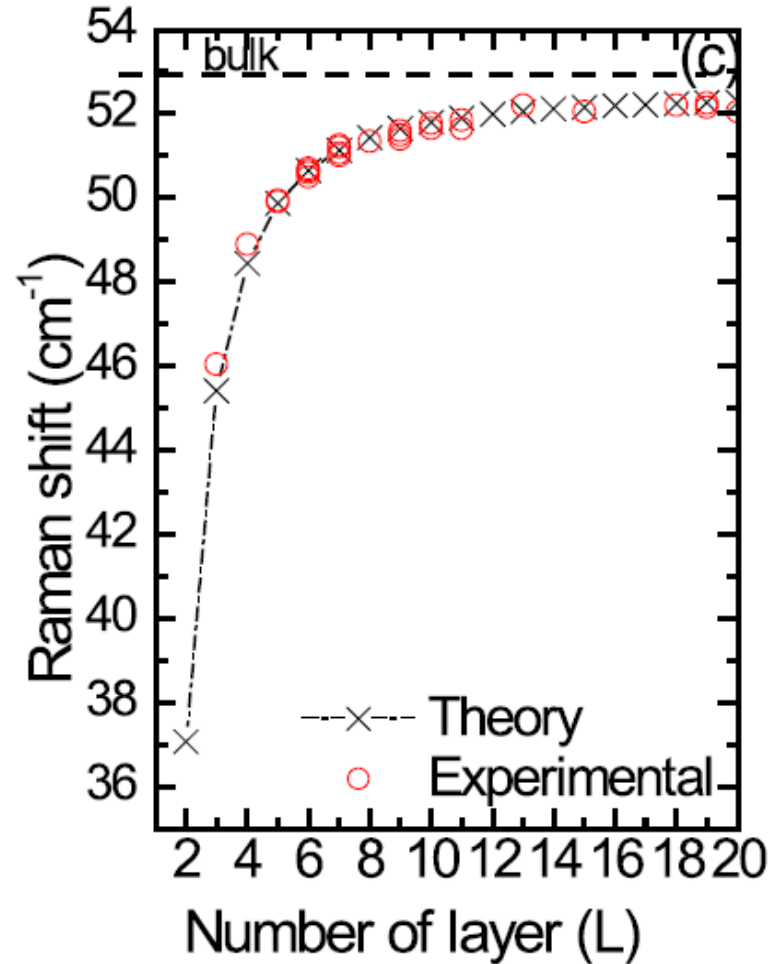
Out-of-plane



In-plane
(Transverse)



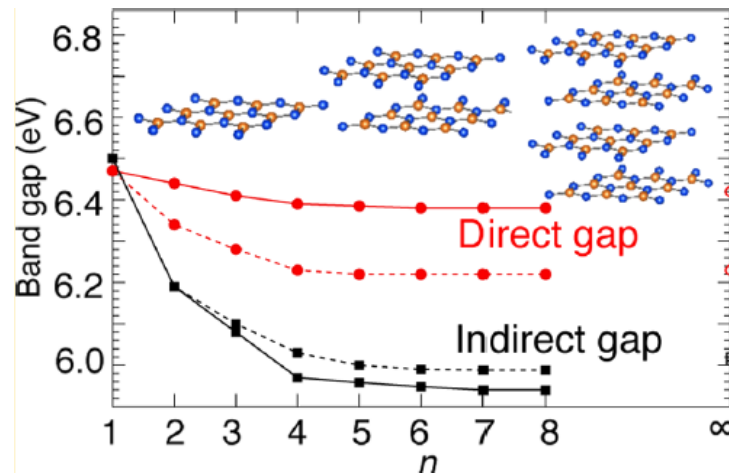
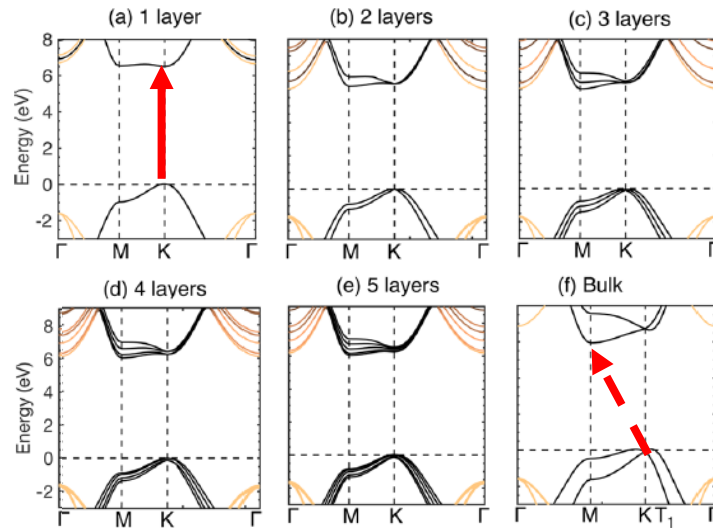
In-plane
(Longitudinal)



Theoretical estimation is done through a linear chain model (each layer interacts only with the adjacent ones)

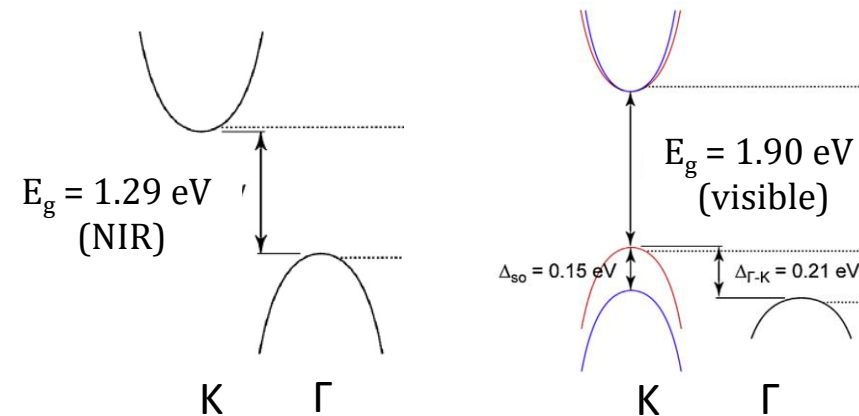
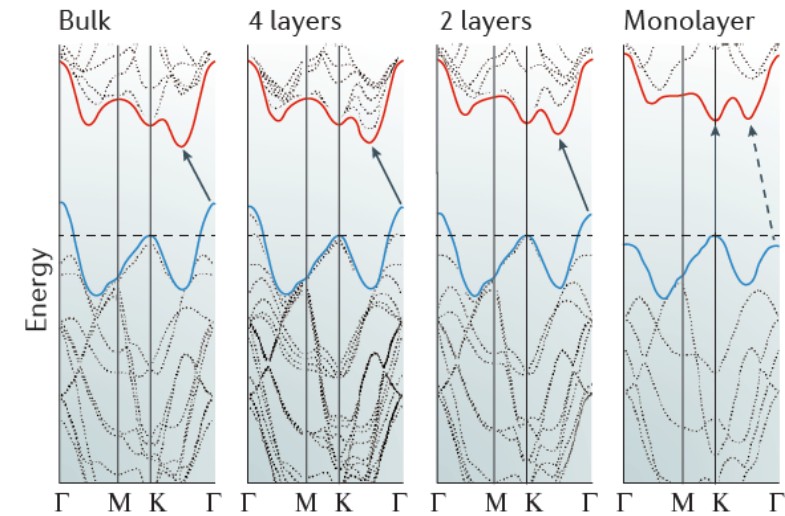
Bulk to monolayer: band structure (1)

h-BN



Wickramaratne et al. J. Phys. Chem. C, 122, (2018)

MoS₂

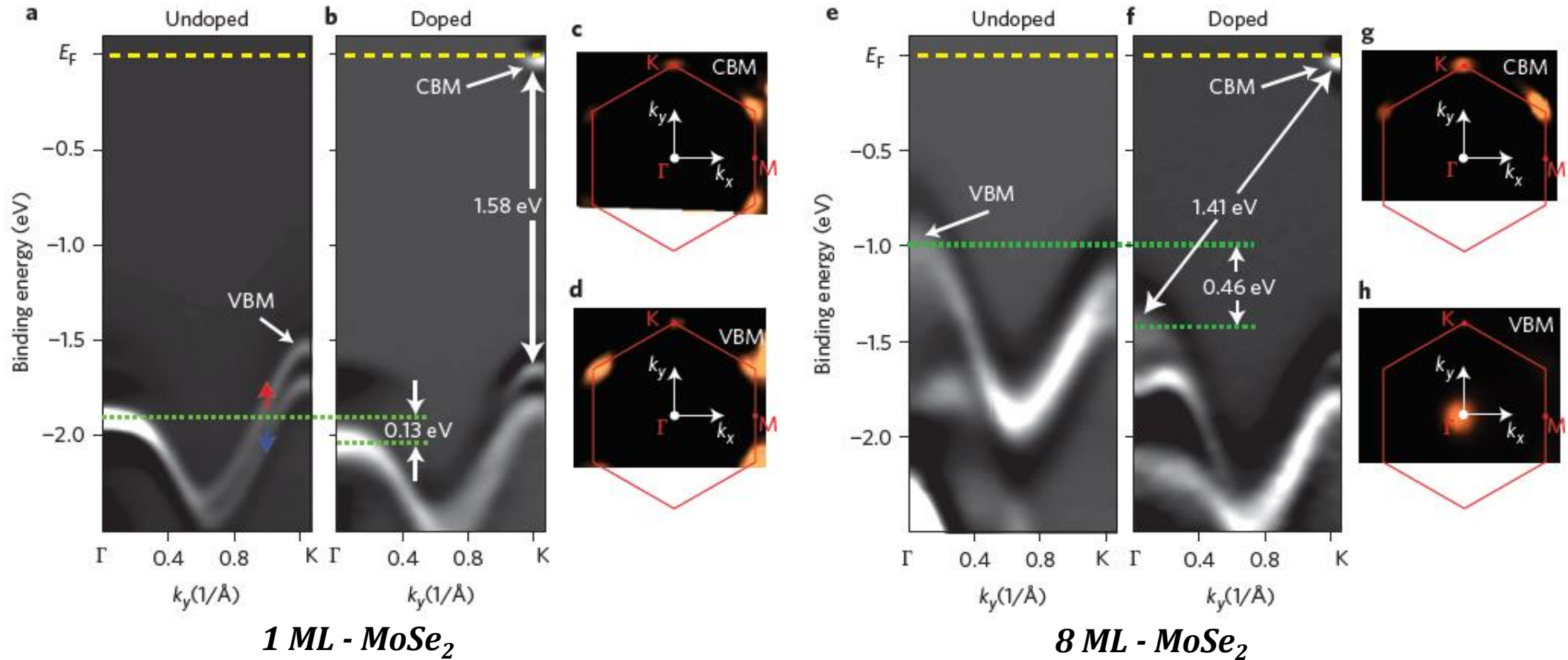


Manzeli et al., Nature Reviews, 2, (2017)

Yazyev, A. Kis, Mater. Today, 18, (2014)

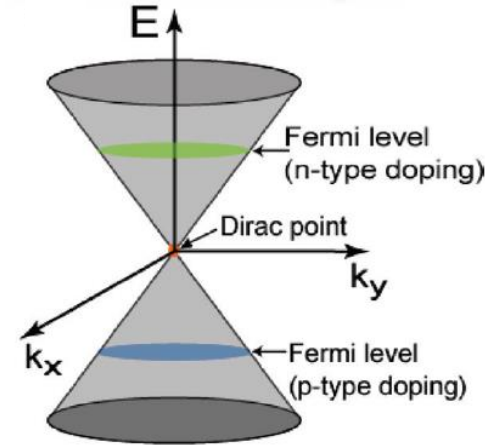
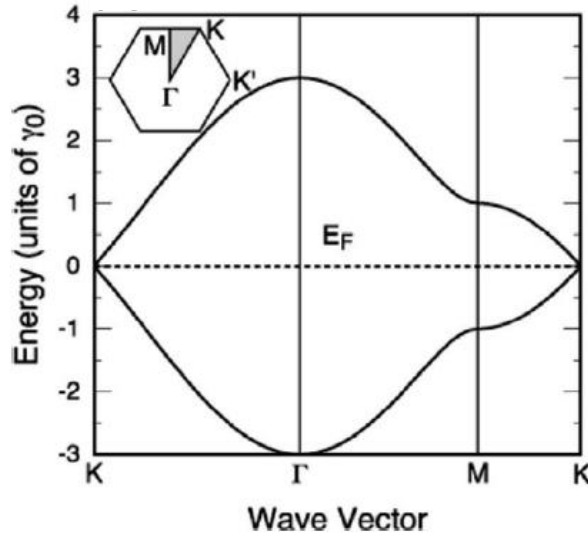
Bulk to monolayer: band structure (2)

Angle Resolved PhotoEmission Spectroscopy (ARPES)



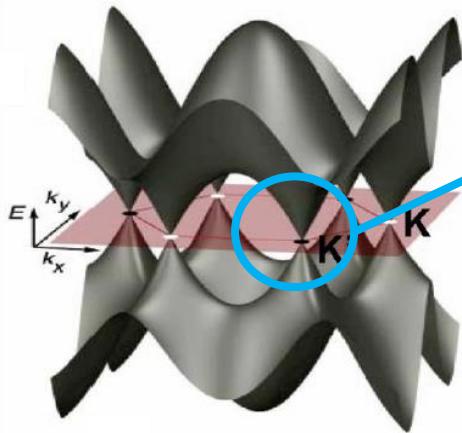
Bulk to monolayer: band structure (3)

Graphene

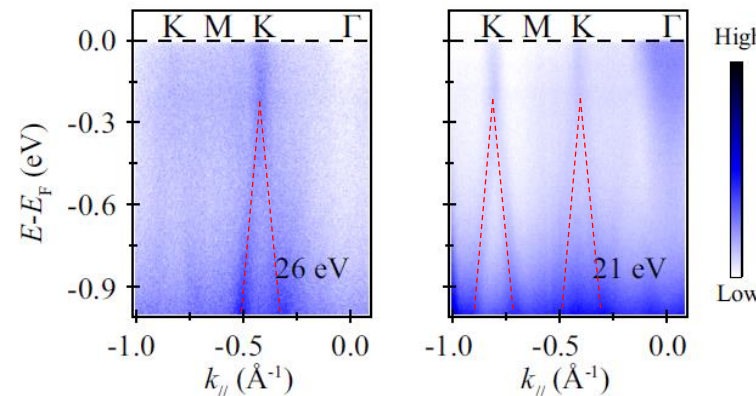


DIRAC CONE:

Linear energy – momentum relationship ($E-k$)

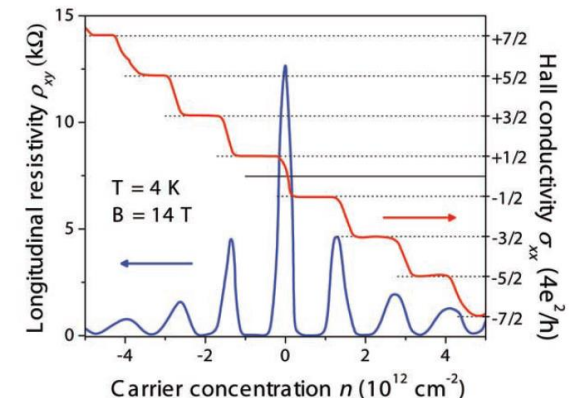


ARPES measurements



Yue, PRB, 108, (2020)

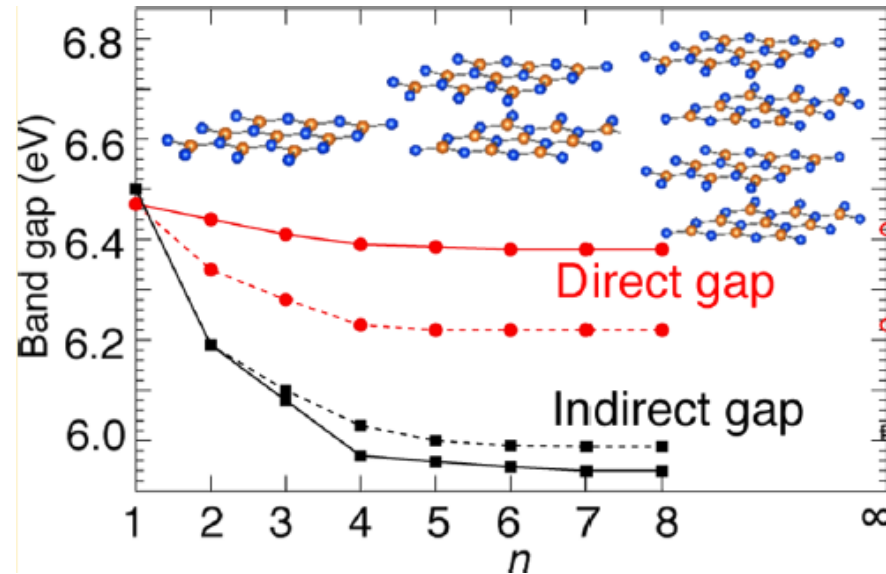
QHE in Dirac Cones



Weiss, Adv. Mater., 24, (2012)

Avouris, NanoLetter, 10, (2010)

Exercise (10 minutes)



Why in 2D crystals the band gap is decreasing with increasing number of layers?

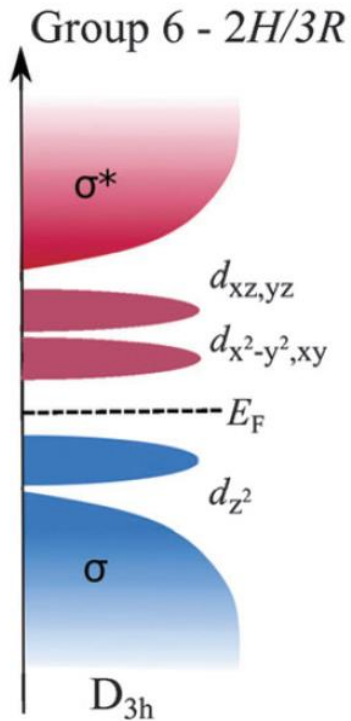
Why are there 4 curves to indicate direct and indirect band gaps of h-BN?

Exercise (5 minutes)

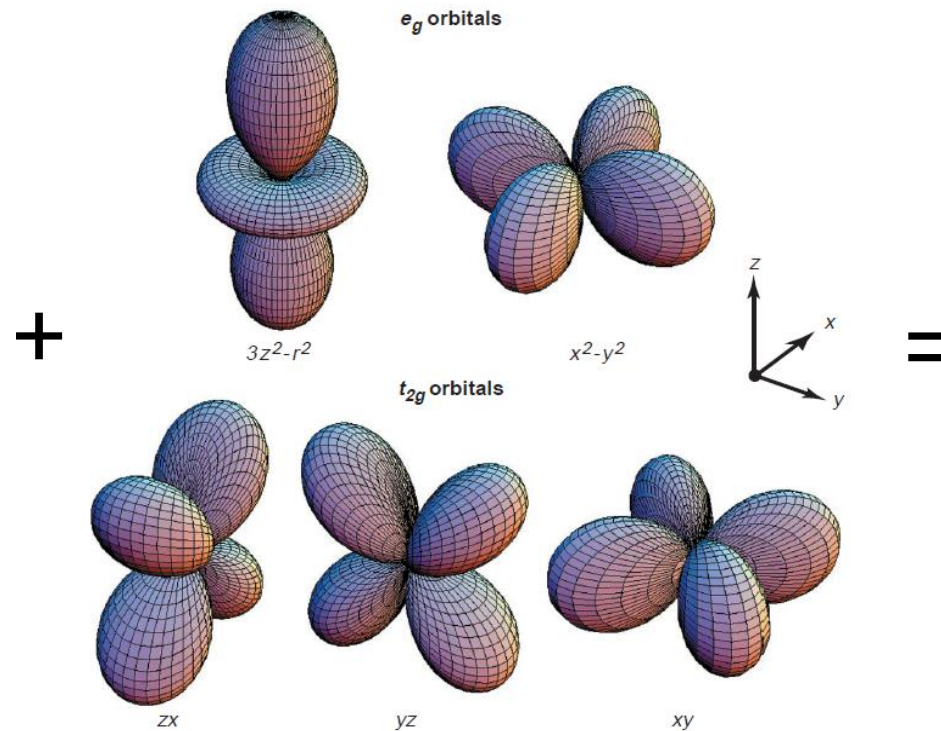
To be solved in Class

Effect of spin-orbit interaction on energy bands

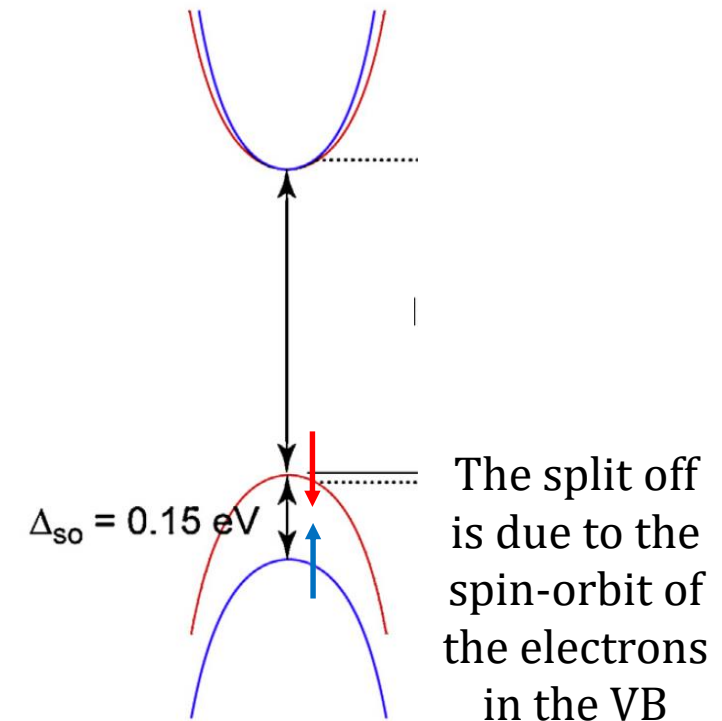
Conduction and Valence band lower levels consists of d-orbitals



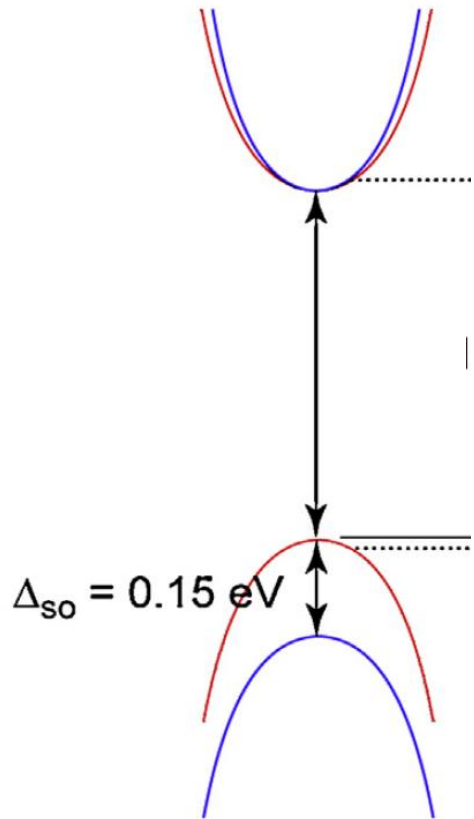
D-orbitals have a high angular momentum



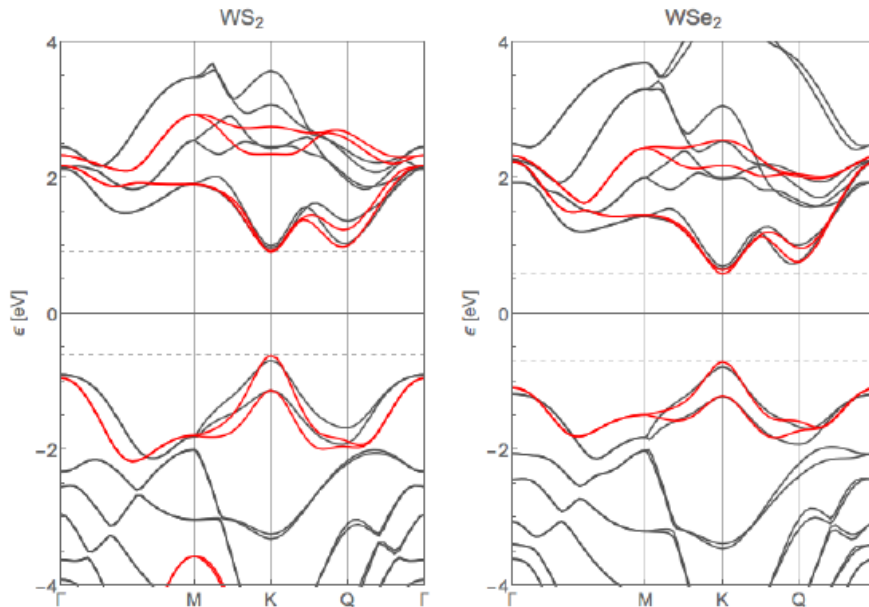
Valence band split off



From spin-orbit interaction to spintronic



WS₂ and WSe₂

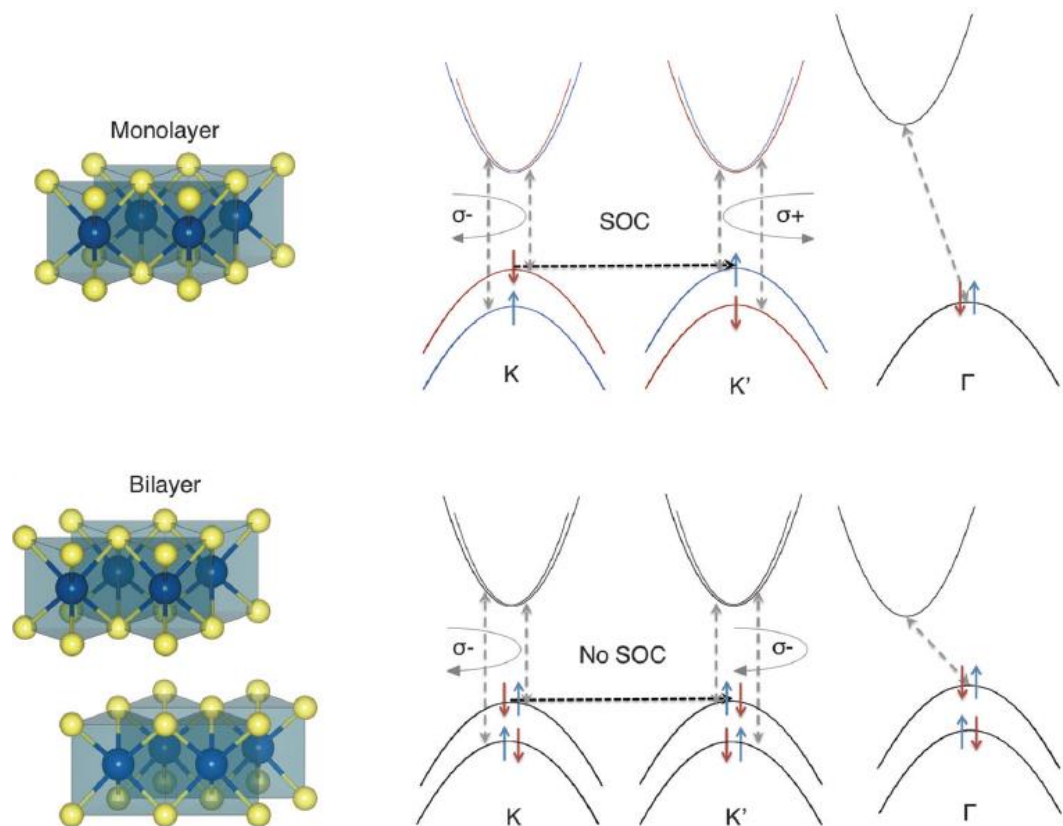


Spintronic: engineering spin split-off by applying external electric and magnetic fields.

Requirement: Materials with high spin-orbit interaction, i.e. materials exhibiting valence split off due to the coupling/decoupling between spin and orbitals

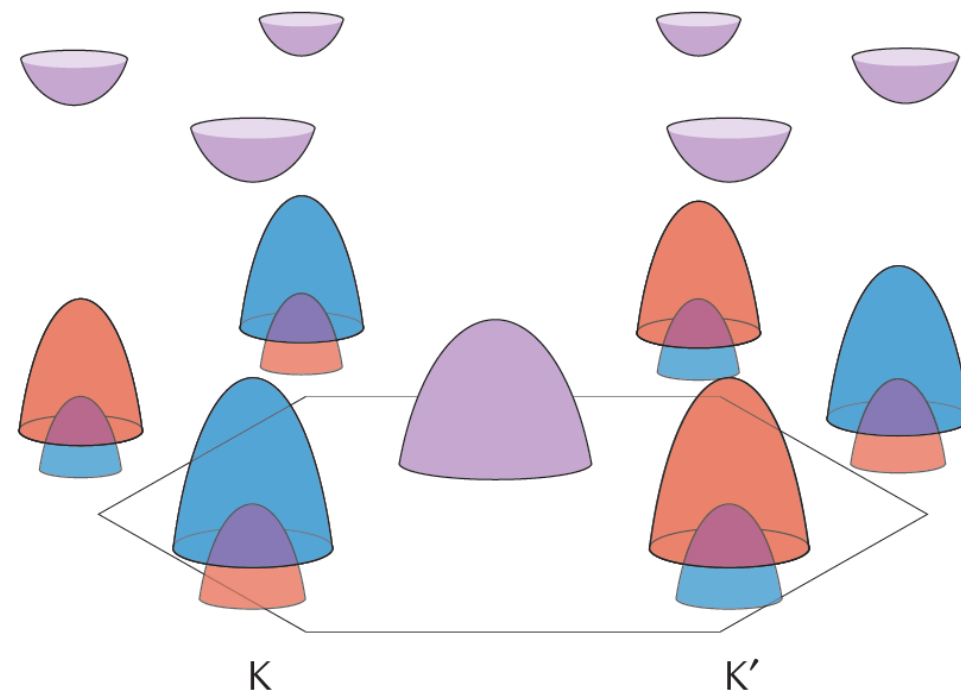
From spintronic to valleytronic

Effect of inversion symmetry on the spin-orbit coupling.



Polarization dependent selection rule for light absorption

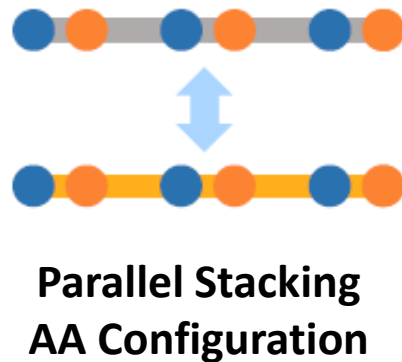
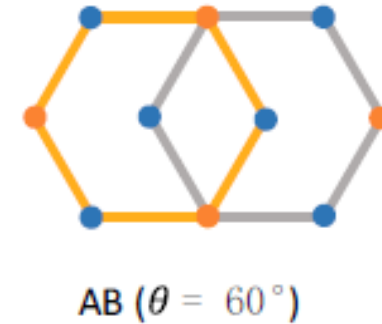
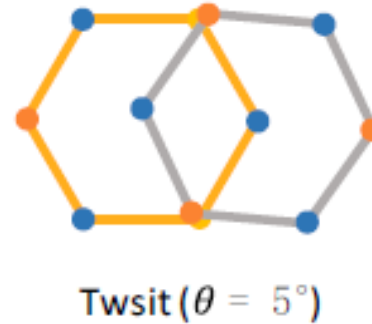
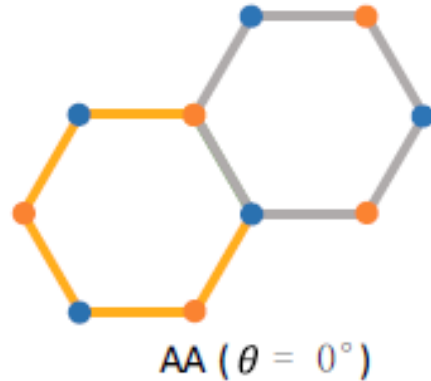
Spin-Valley Locking



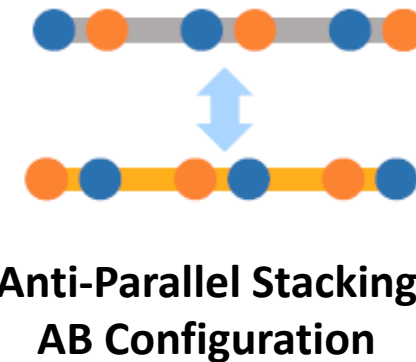
Valleytronic: engineering functional properties on the base of valley-related spin-orbit coupling.

Layer sequencing: 2D stackings

Multi-layer configurations

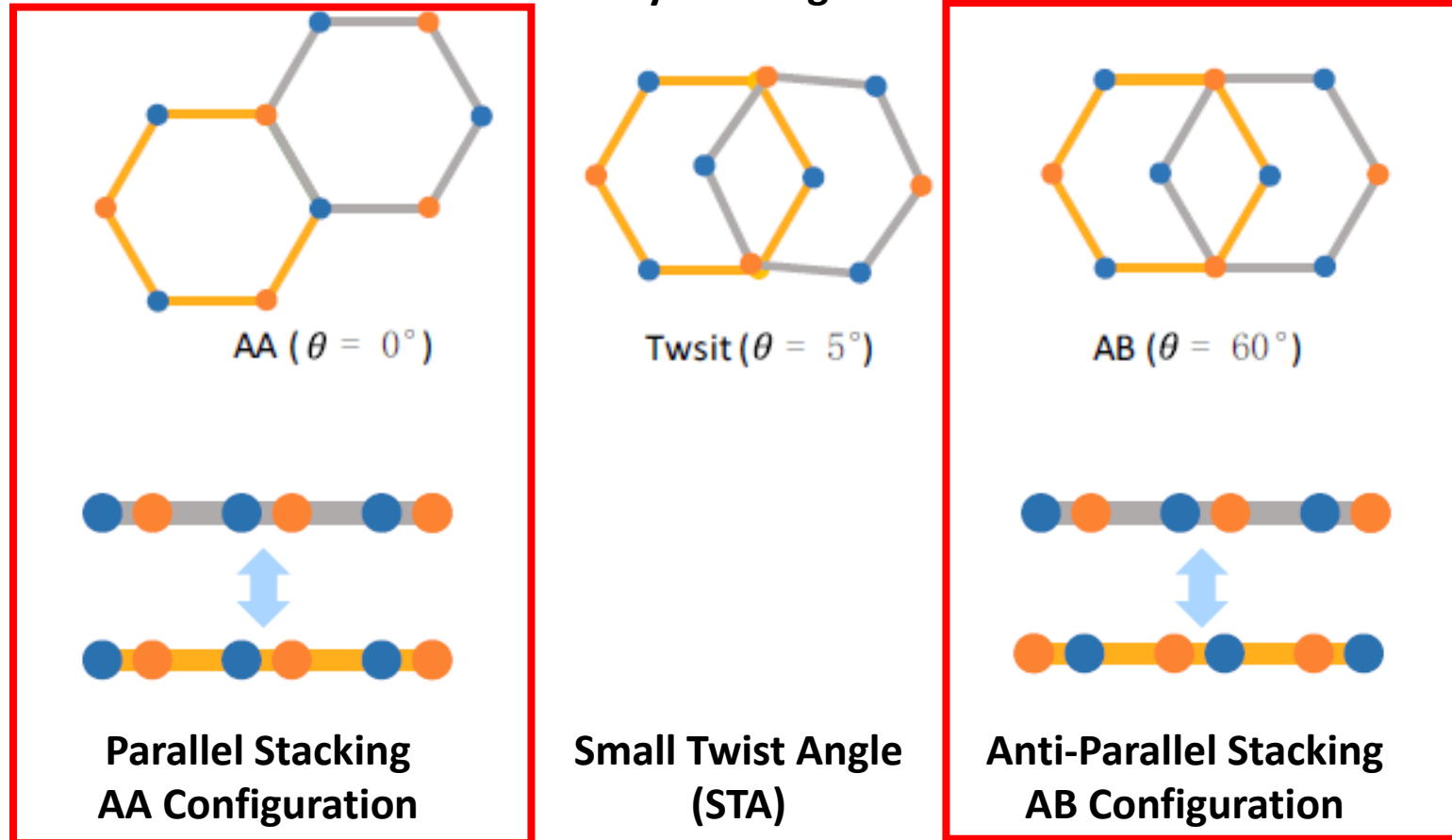


Small Twist Angle
(STA)



Layer sequencing: 2D stackings

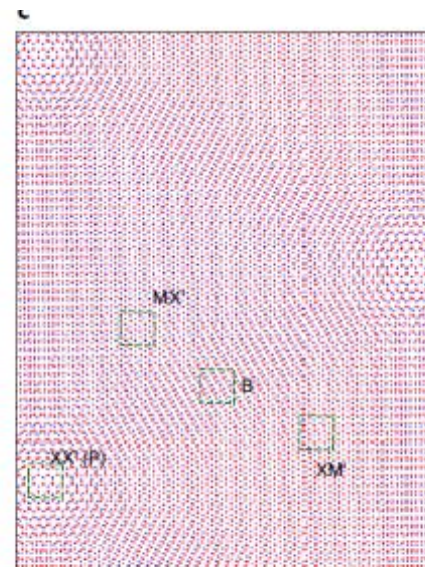
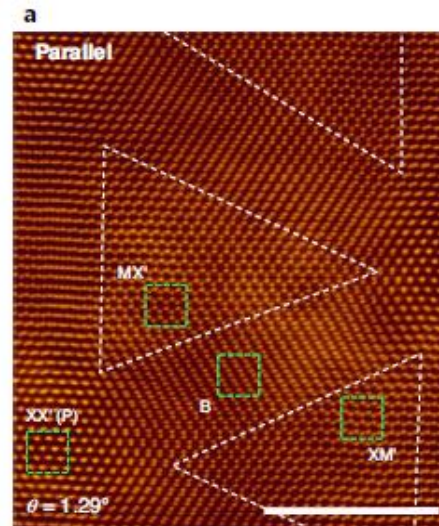
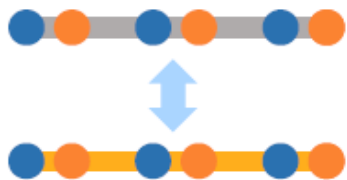
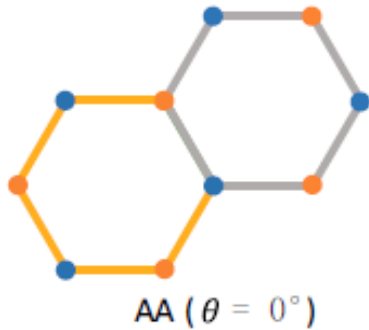
Multi-layer configurations



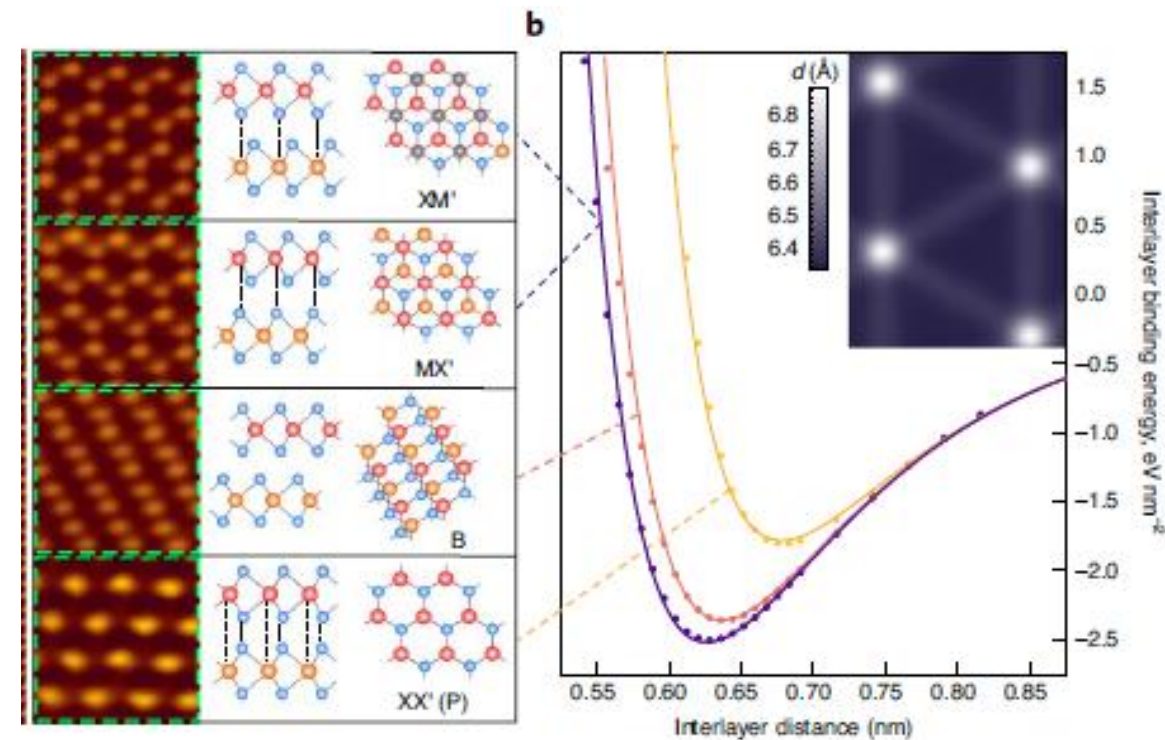
Layer sequencing: Parallel Stacking

WS₂ Parallel Bilayer ($\theta = 0^\circ$)

Parallel configuration (AA)

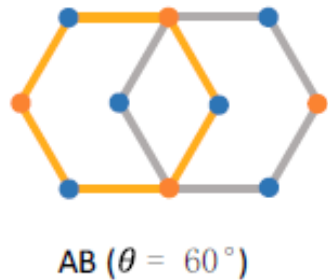


Calc.

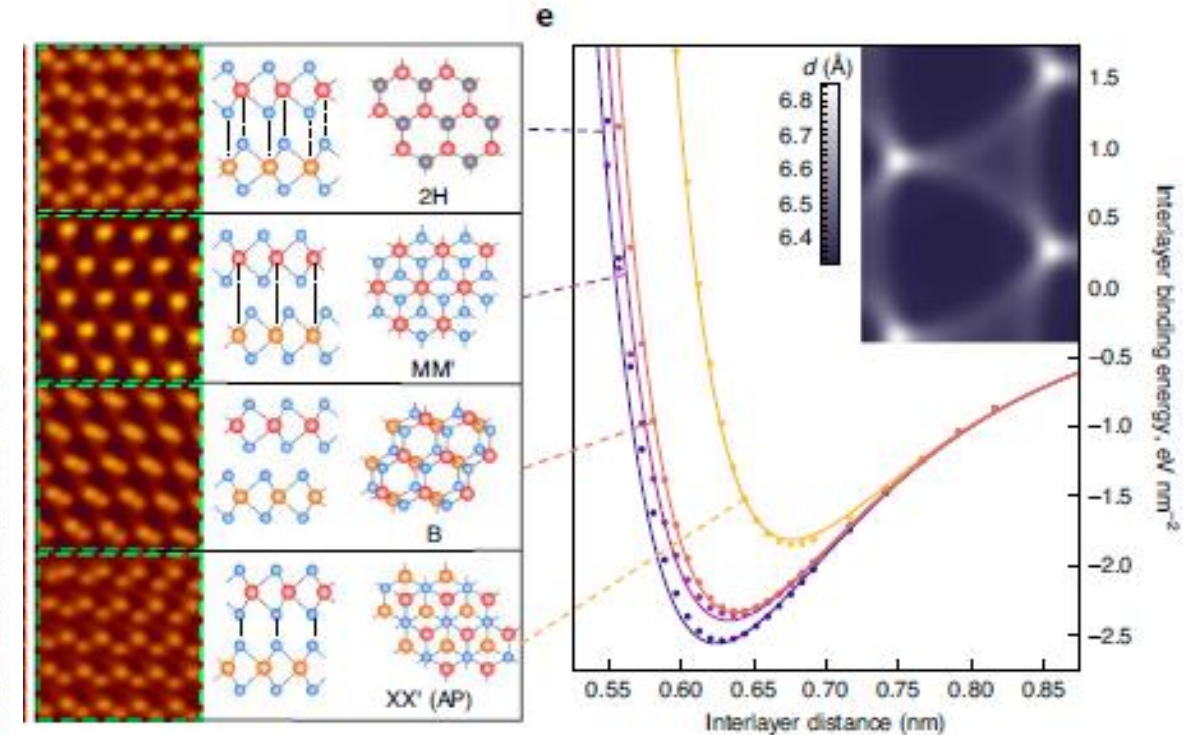
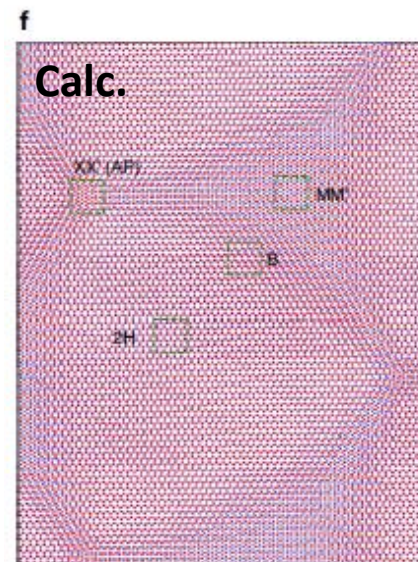
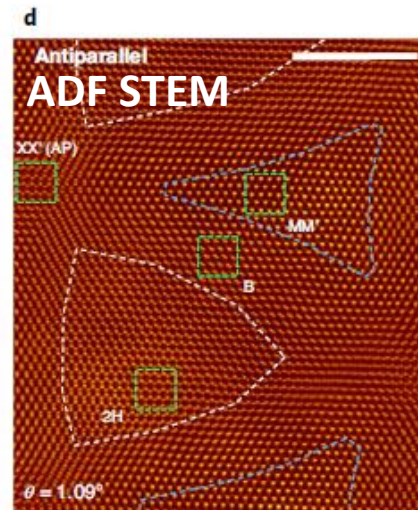


Layer sequencing: Anti-Parallel Stacking

Anti-parallel configurations (AB)

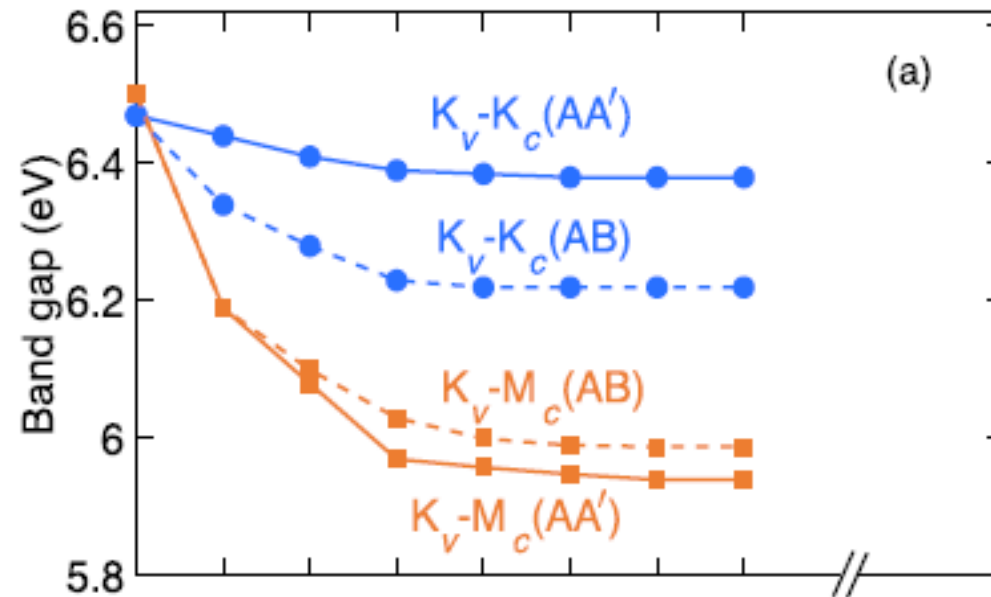
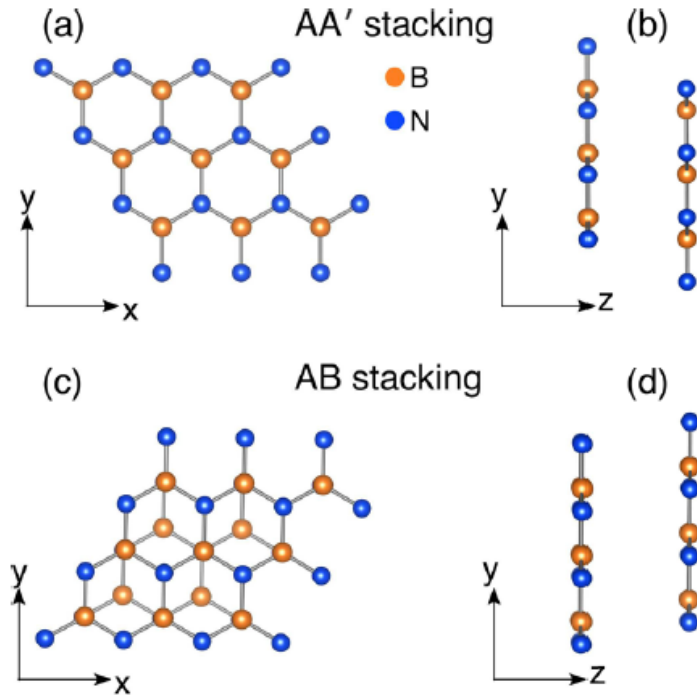


WS₂ Anti-Parallel Bilayer ($\theta = 60^\circ$)



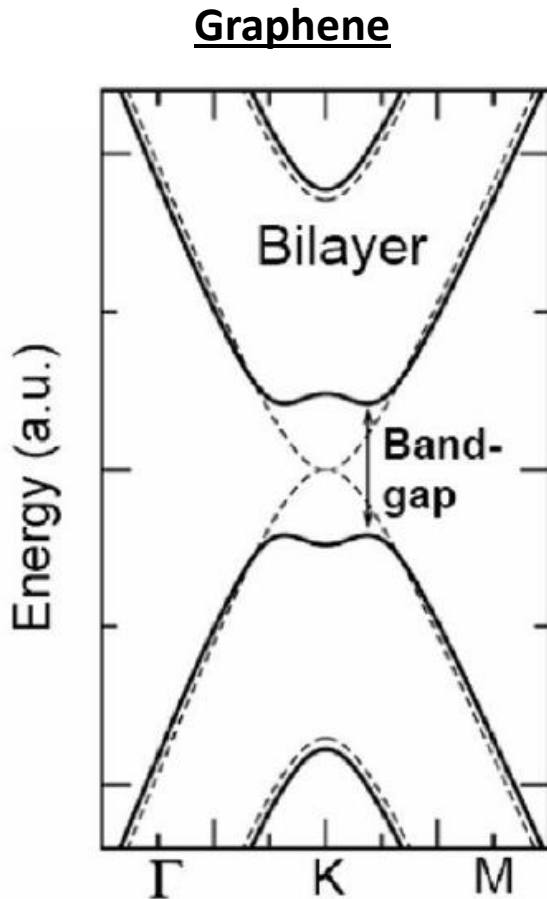
Effect of parallel/anti-parallel stacking (1)

h-BN (previous example)



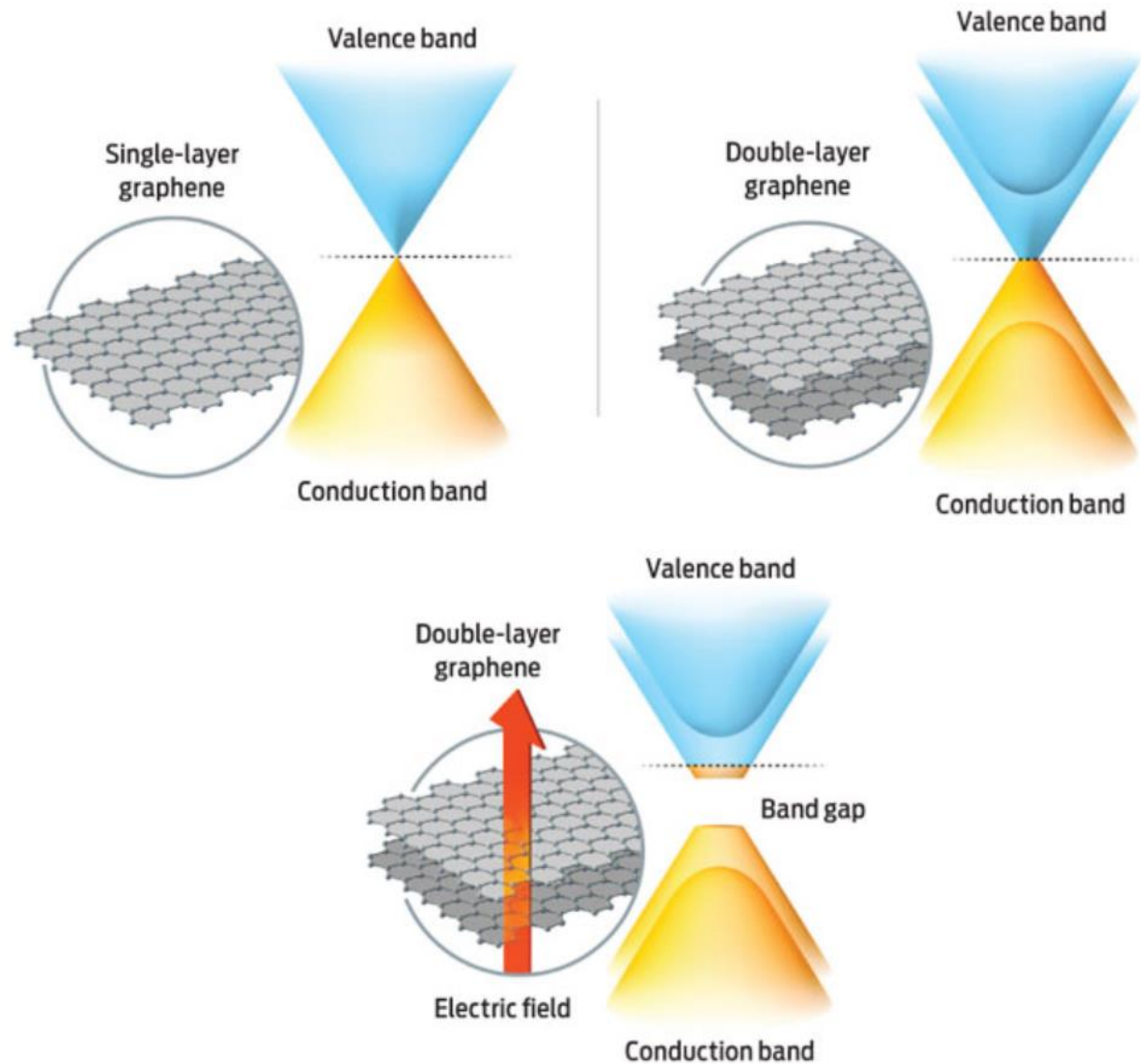
Since the interlayer distance varies with the stacking sequence, different bandgap are expected for AA' and AB configurations.

Effect of parallel/anti-parallel stacking (2)



It is possible to open a band-gap in AB bilayer graphene by applying an electric field perpendicular to the layers.

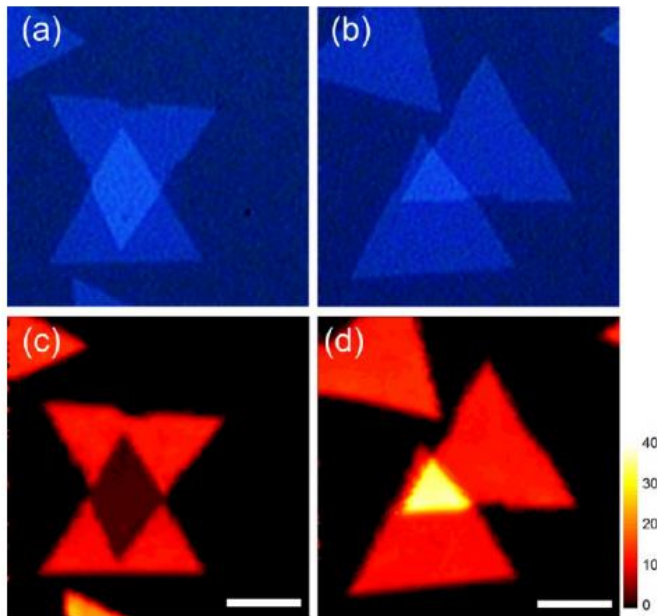
McCann, Phys. Rev. B, 74 (2006)



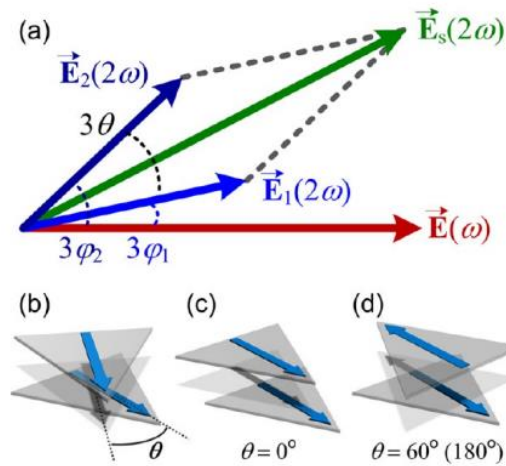
Effect of parallel/anti-parallel stacking (3)

Second Harmonic Generation

Optical microscopy image of MoS₂ flakes



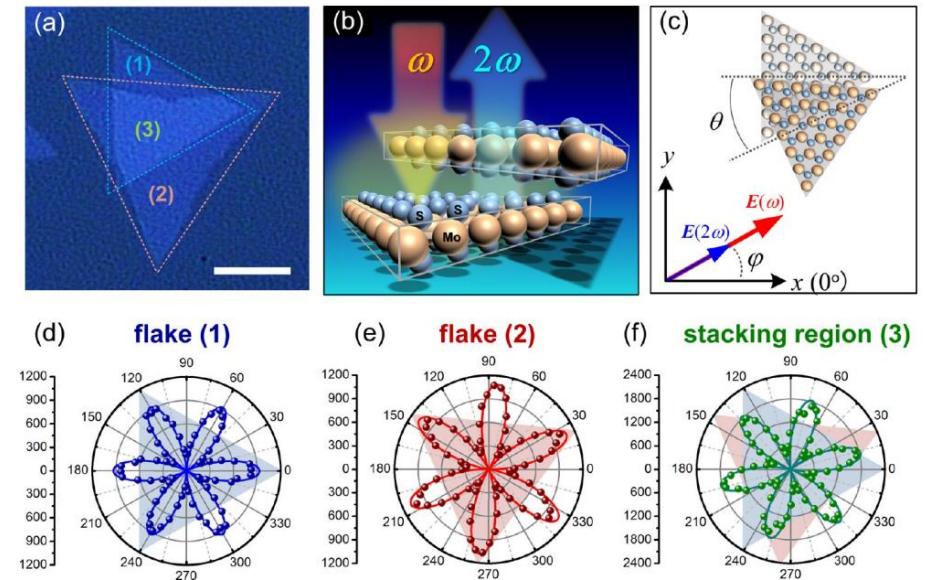
SHG map



Anti-parallel:
Destructive
interference

Parallel:
Constructive
interference

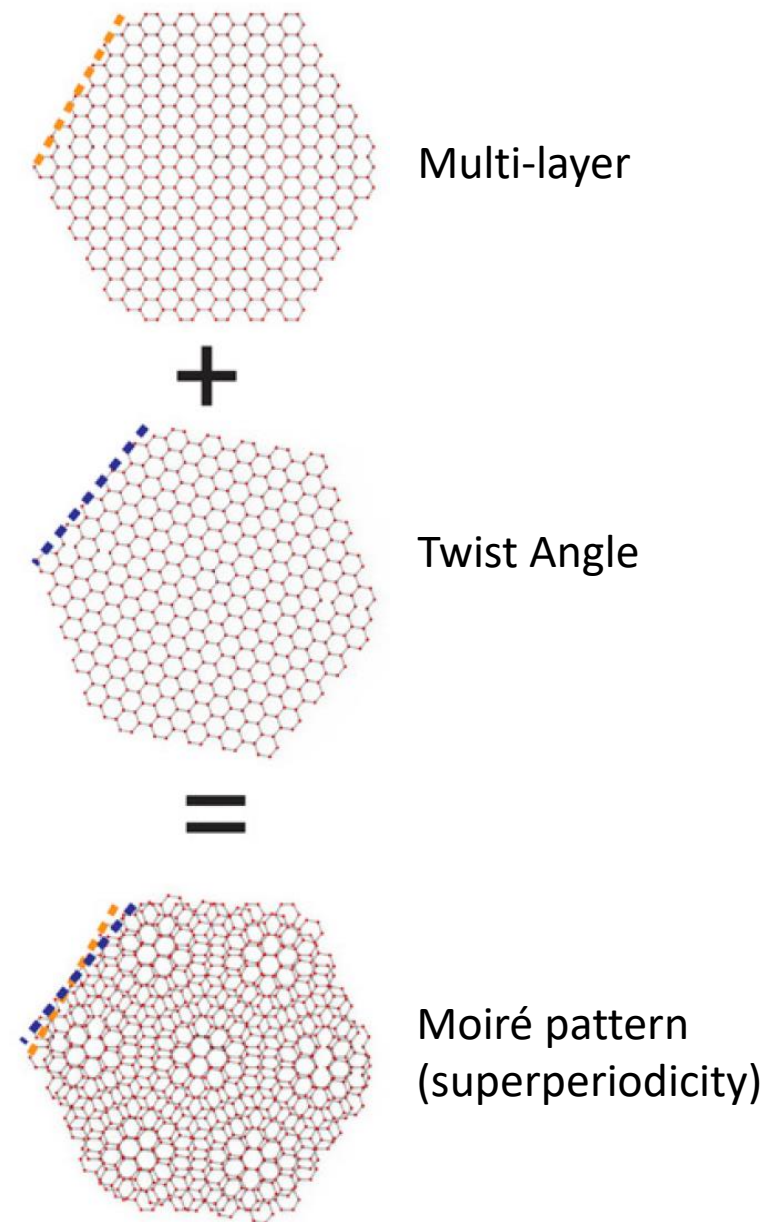
Polarization of SH from bilayers (Polar plot)



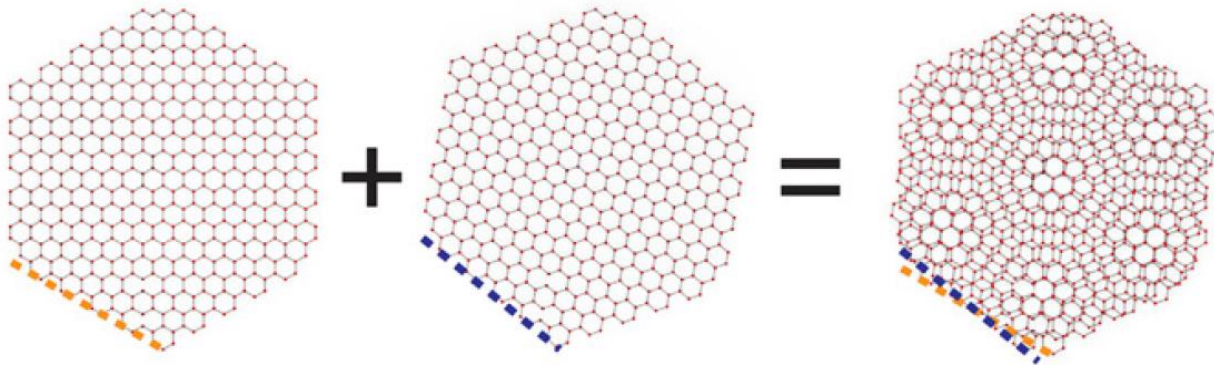
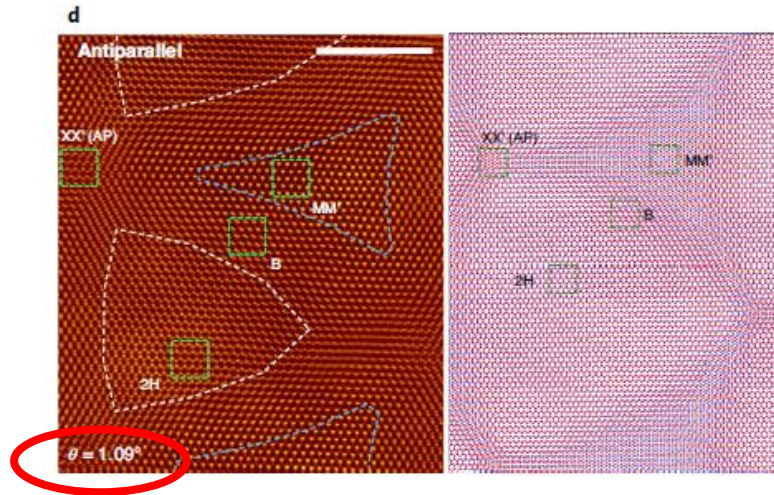
The polarization of the SH emission from a bilayer is a combination of the monolayer emission and the twisting angle



Credit to Prof. Bosco Yu, University of Victoria

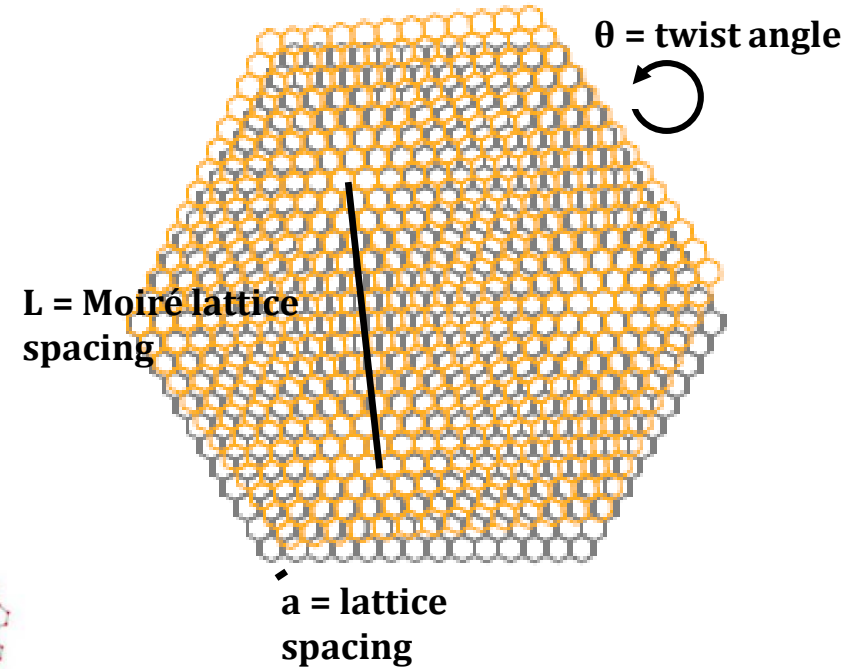


Small Twisted Angle: Moiré Patterns



Moiré patterns or Moiré superlattice:
long-range ordered sequence of crystal lattices

Kim et al., PNAS, 114, (2017)



For $\theta < 3^\circ$ (small twist angle):

$$L = \frac{a}{2 \sin\left(\frac{\theta}{2}\right)}$$

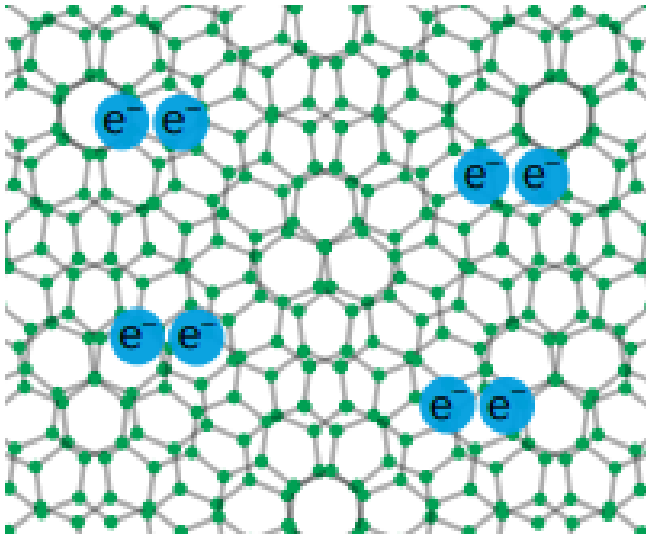
**Superperiodicity
constant**

Cheng et al., Chin. Phys. B, 28, (2019)

Weston et al., Nature Nanotechn., 15, (2020)

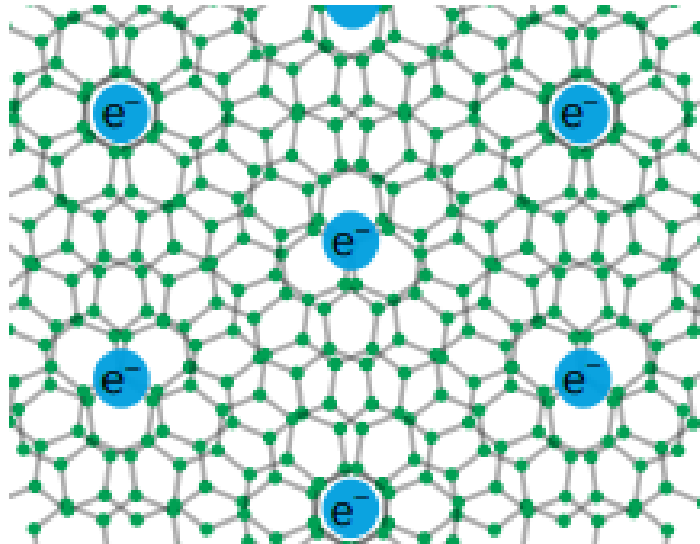
Properties of Moiré patterns

Superconductivity



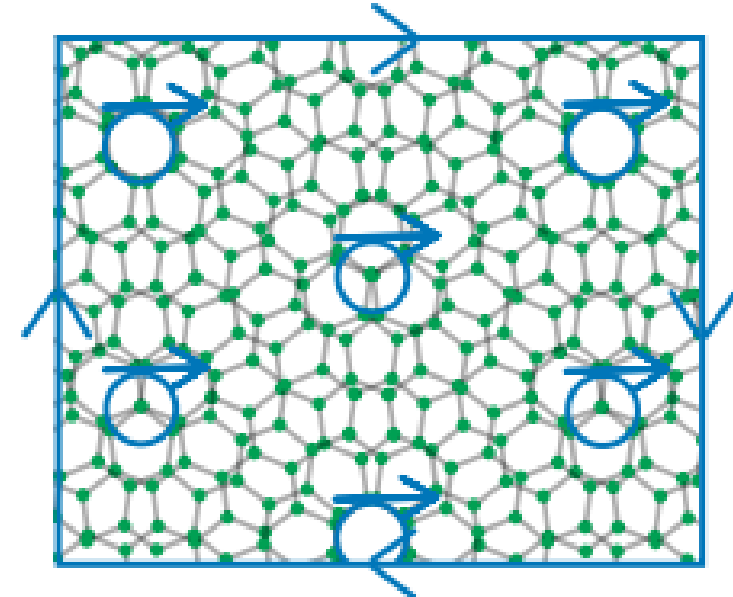
Transition temperature
dependent on θ .

Mott insulator states



Highly localized states (whose
density depends on θ).

Orbital magnetism



Moiré structuring of local
magnetic moments

How to tune the 2D properties?

DOPING

Substitutional doping
Charge Transfer
Intercalation
Electrostatic doping

PASSIVATION

Defect passivation
Surface encapsulation

HETEROSTRUCTURING

Defect passivation
Surface encapsulation

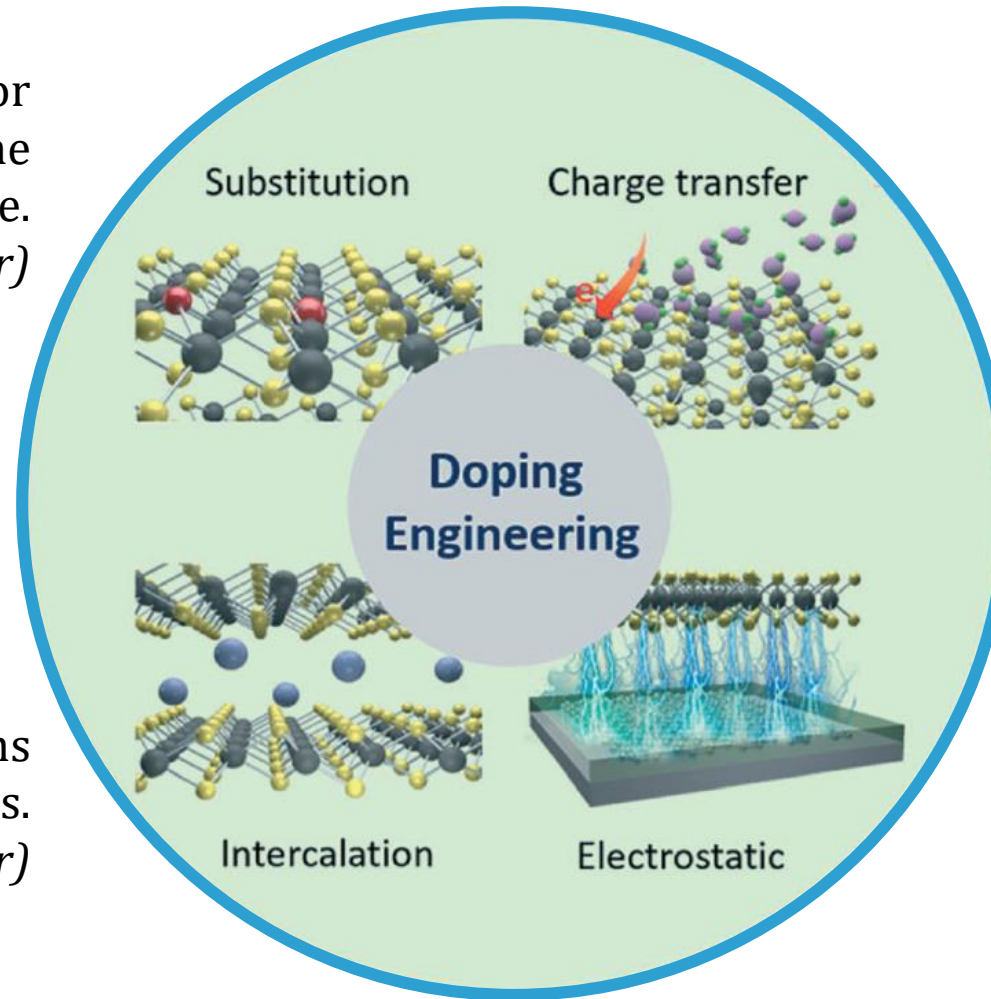
Doping Strategies

Substitution of metal or chalcogen atoms in the lattice.
(Monolayer/Multilayer)

Charge transfer from atoms/molecules adsorbed on the surface to the layer.
(Monolayer)

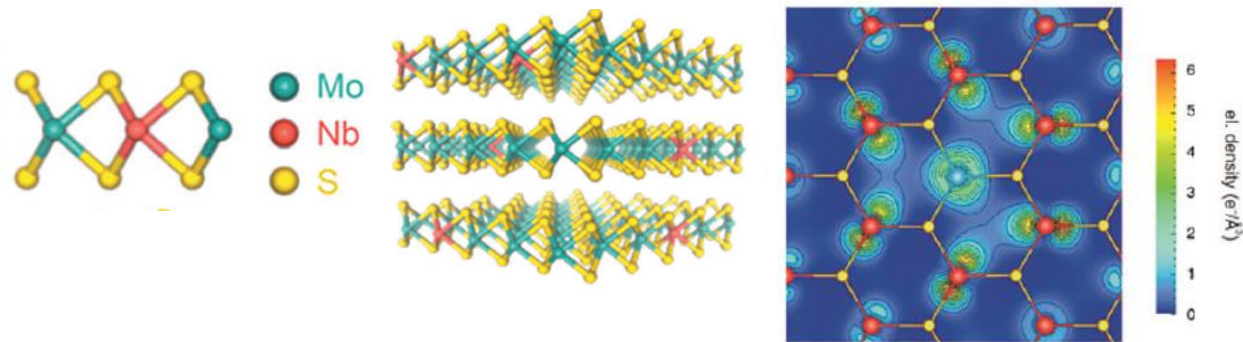
Intercalation of atoms between crystal layers.
(Multilayer)

Electrostatic charge pumping.*
(Mono-, Bi-Layer)

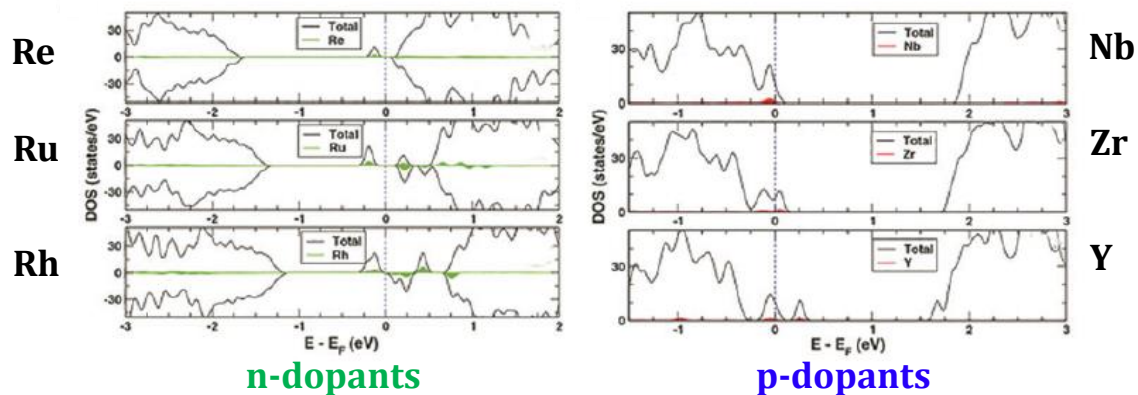


Substitutional Doping (1)

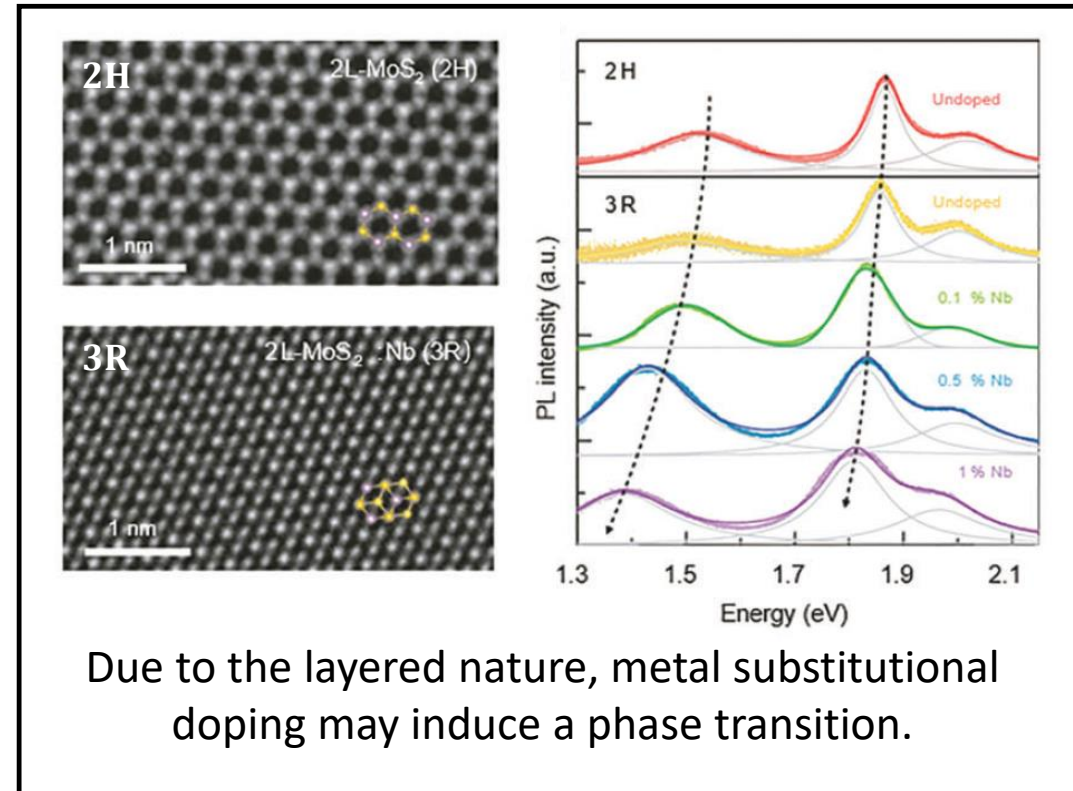
Substitution of metal atoms in the lattice ($\text{Mo}, \text{W} \rightarrow \text{T}$)



Electronic density of states of T:MoS₂



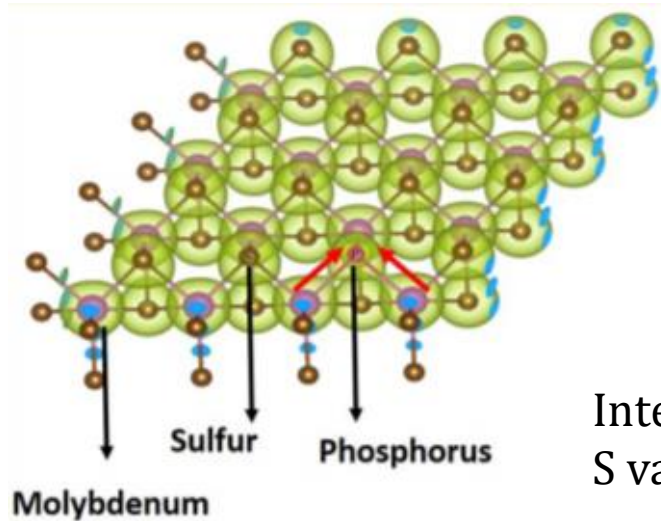
Luo et al., Nanoscale Horiz., 4, (2019)



21 Sc Scandio 44,956	22 Ti Titanio 47,867	23 V Vanadio 50,942	24 Cr Cromo 51,996	25 Mn Manganese 54,938	26 Fe Ferro 55,845	27 Co Cobalto 58,933	28 Ni Nichel 58,693	29 Cu Rame 63,546	30 Zn Zinco 65,38	31 Ga Gallio 69,7
39 Y Ittrio 88,906	40 Zr Zirconio 91,224	41 Nb Niobio 92,906	42 Mo Molibdeno 95,95	43 Tc Tecnezio (98)	44 Ru Rutenio 101,07	45 Rh Rodio 102,91	46 Pd Palladio 106,42	47 Ag Argento 107,87	48 Cd Cadmio 112,41	49 In Indio 114
57-71	72 Hf Afrio 178,49	73 Ta Tantalio 180,95	74 W Tungsteno 183,84	75 Re Renio 186,21	76 Os Osmio 190,23	77 Ir Iridio 192,22	78 Pt Platino 195,08	79 Au Oro 196,97	80 Hg Mercurio 200,59	81 Tl Tallio 204

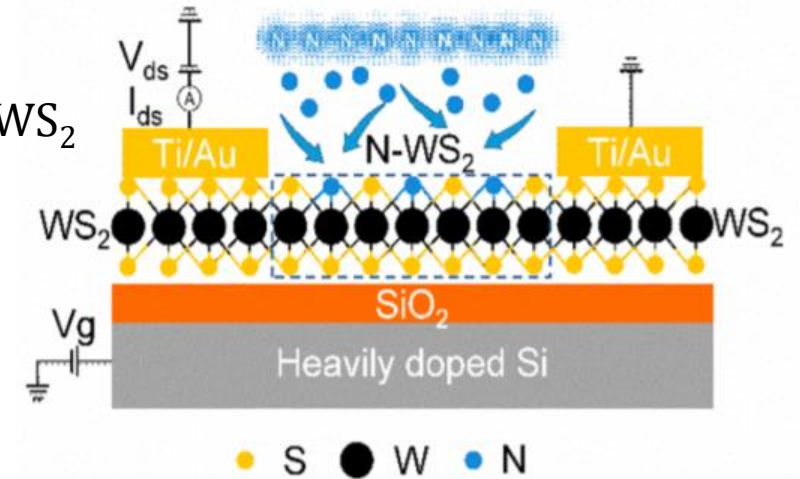
Substitutional Doping (2)

Ion implantation of P and N

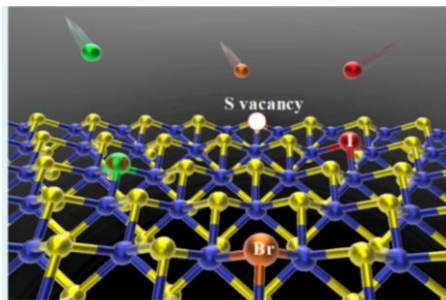


p-dopants

Substitutional N in WS₂



Halide assisted Growth



n-dopants

Cl, Br, I in S vacancy sites
Passivation effect

Nipane et al., ACS Nano, 10, (2016)

Tang et al. ACS Nano, 12, (2018)

Wang et al., ACS Appl. Mater. Interfaces, 12, (2020)

Substitutional doping resuming table

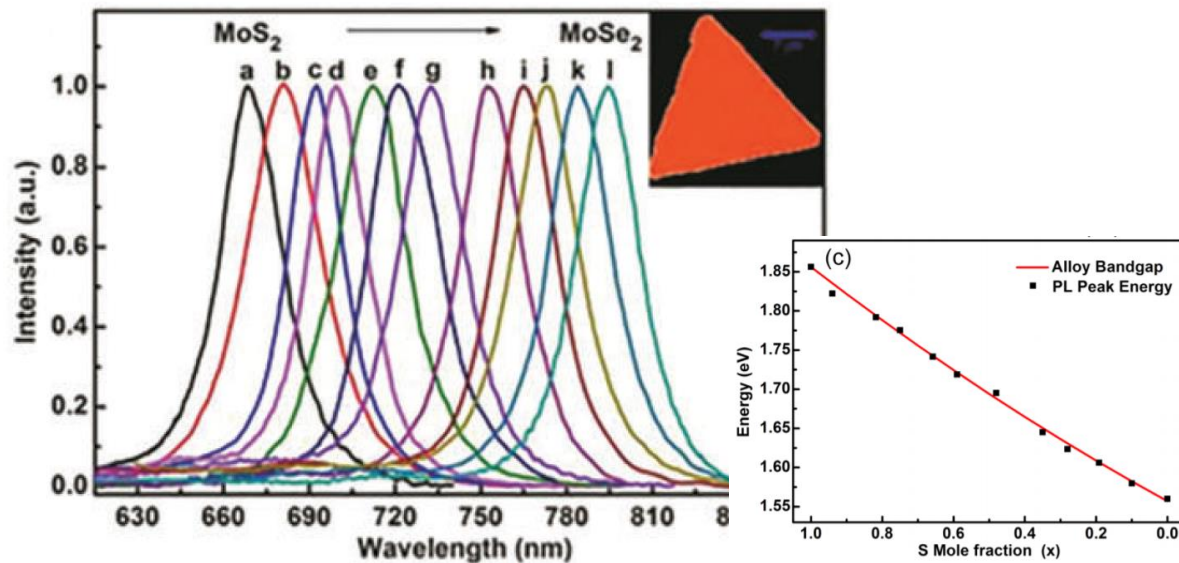
MX _n	Dopant	Type	Concentration [cm ⁻²]	Mobility [cm ² V ⁻¹ s ⁻¹]	Ref.
MoS ₂	Nb	p	1.8×10^{14}	14	32
	P	p	$10^{10}-10^{12}$	137.7	33
	Re	n	5.5×10^{12}	—	80
MoSe ₂	W	p	4.0×10^{11}	1.6	86
WS ₂	N	p	3.83×10^{11}	1.7	87
	Cl	n	6.0×10^{11}	60	88
WSe ₂	S	n	—	68.2	89

2D Alloys

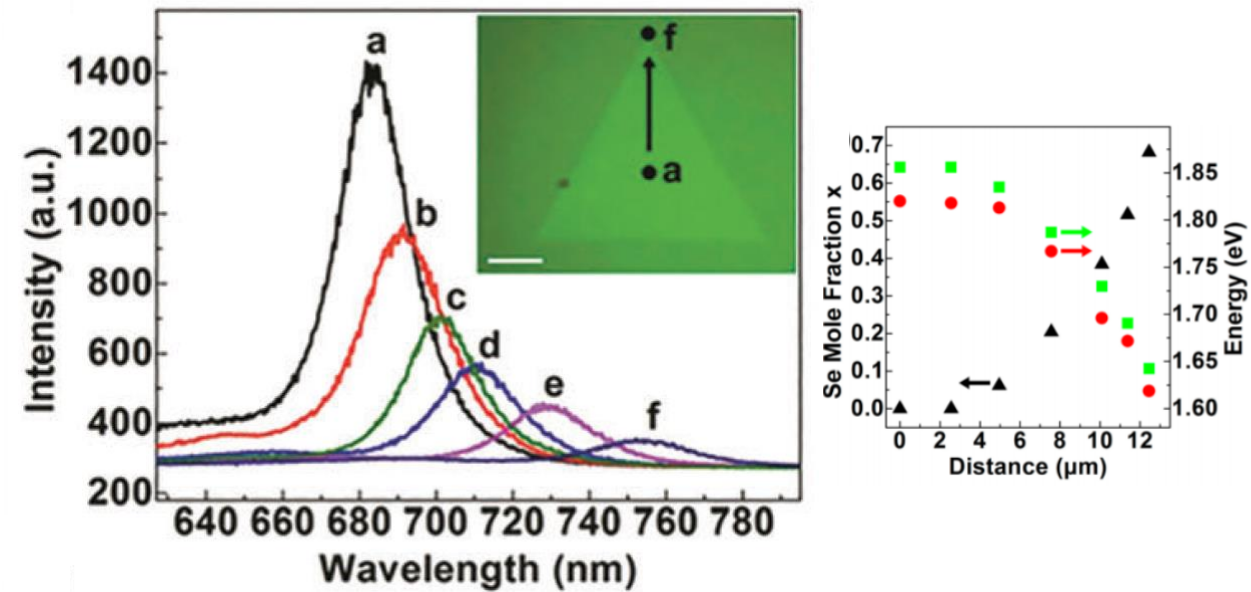
Alloying ~ Isoelectronic doping

Metal and chalcogen alloying induces a modification of the conduction or valence band, directly impacting the band gap and the functional properties.

PL spectra of homogeneous $\text{MoS}_2\text{Se}_{2(1-x)}$



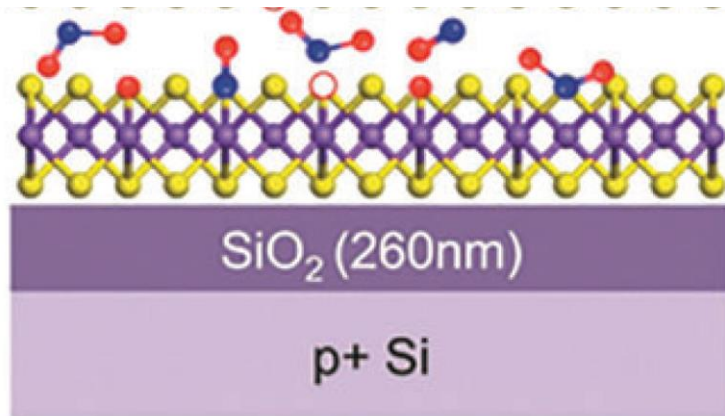
PL spectra of gradient $\text{MoS}_2\text{Se}_{2(1-x)}$



Charge Transfer Doping (1)

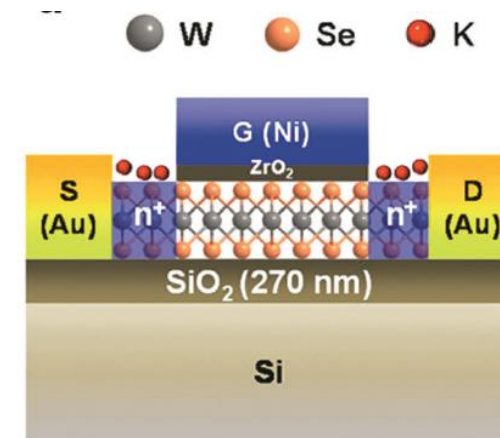
Doping occurs through charge transfer from/to species with different chemical nature which are not chemically bonded with the atomic layer

Gaseous molecules can adsorb on the surface and induce charge transfer (adatom dopants).



TBN: Adsorption occurs on preferential sites such as grain boundaries or vacancies.

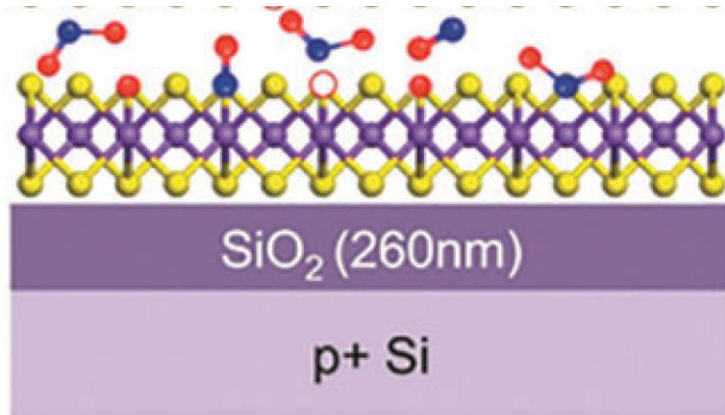
Metal atoms provide electrons/holes to the layer depending on the relative work functions.



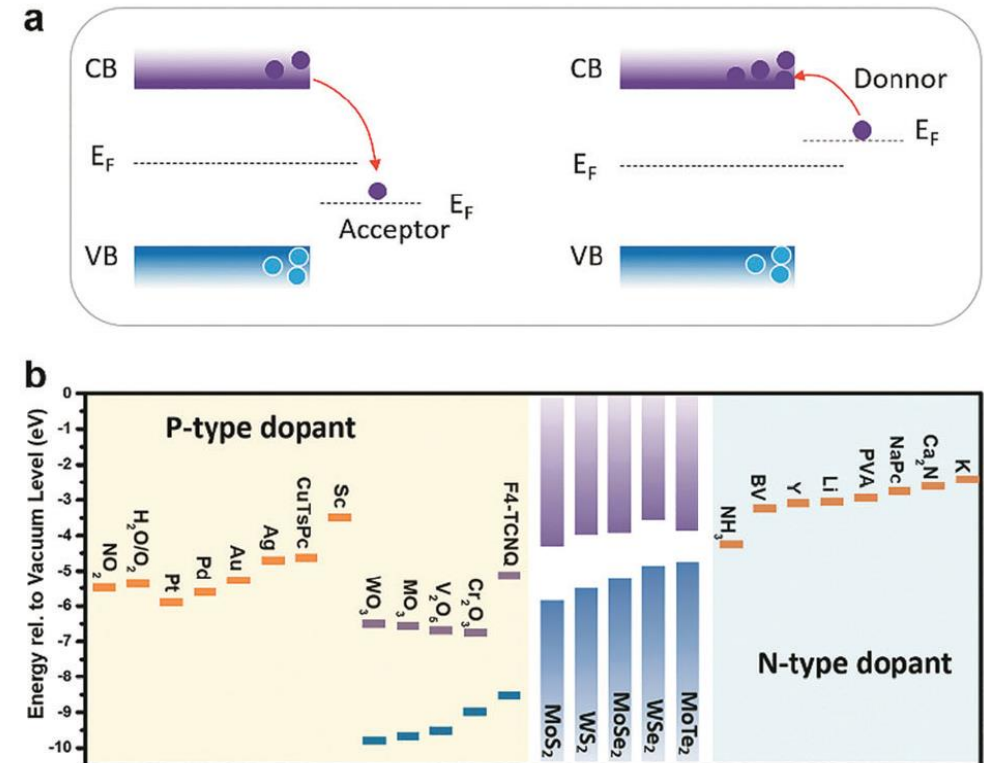
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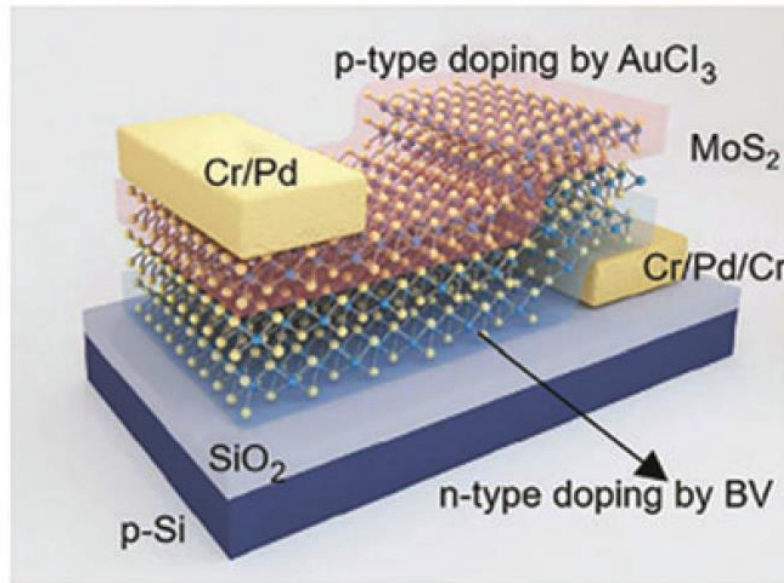


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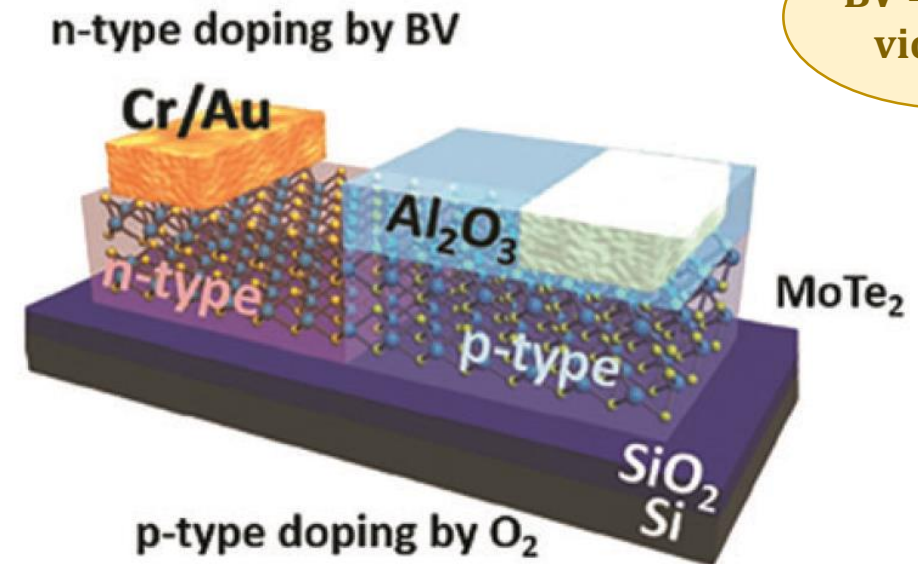


Charge Transfer Doping (2)

Vertical p-n junction



Lateral (Horizontal) p-n junction

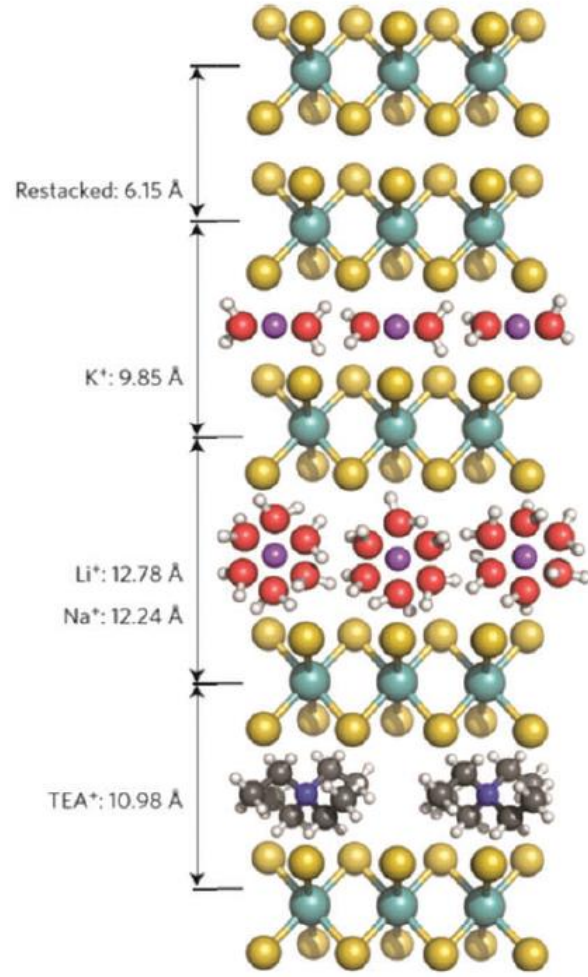


BV = Benzyl
viologen

Charge transfer allows to dope the material after the synthesis (less impact on the atom arrangement) and it is convenient to engineer selected areas of interest.

Intercalation Doping

Example of intercalation doping in MoS₂

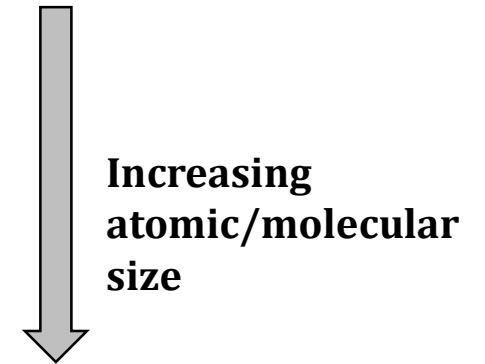


Intercalation is able to modulate the crystal lattice and electronic structure of host materials, as well as providing charges (depending on the donor/acceptor nature of the foreign atoms).

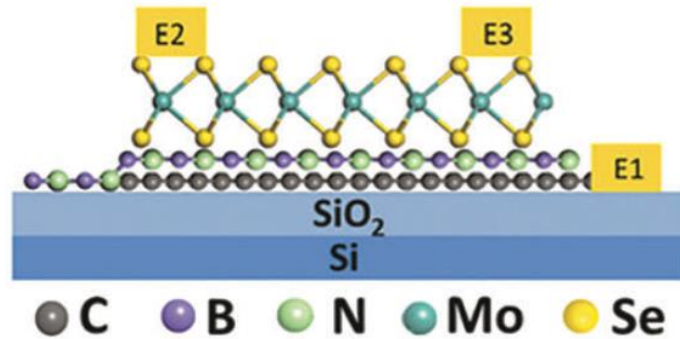
The larger the size of the foreign impurity, the larger the distortion of the crystal and thus the effect on the electronic structure.

Typical intercalation doping is obtain through:

- *Hydrogen*
- *Alkali Metals (Li, Na, K)*
- *Heavy Metals (Cu, Co)*
- *Organic compounds (Triethylamine)*



Electrostatic Doping



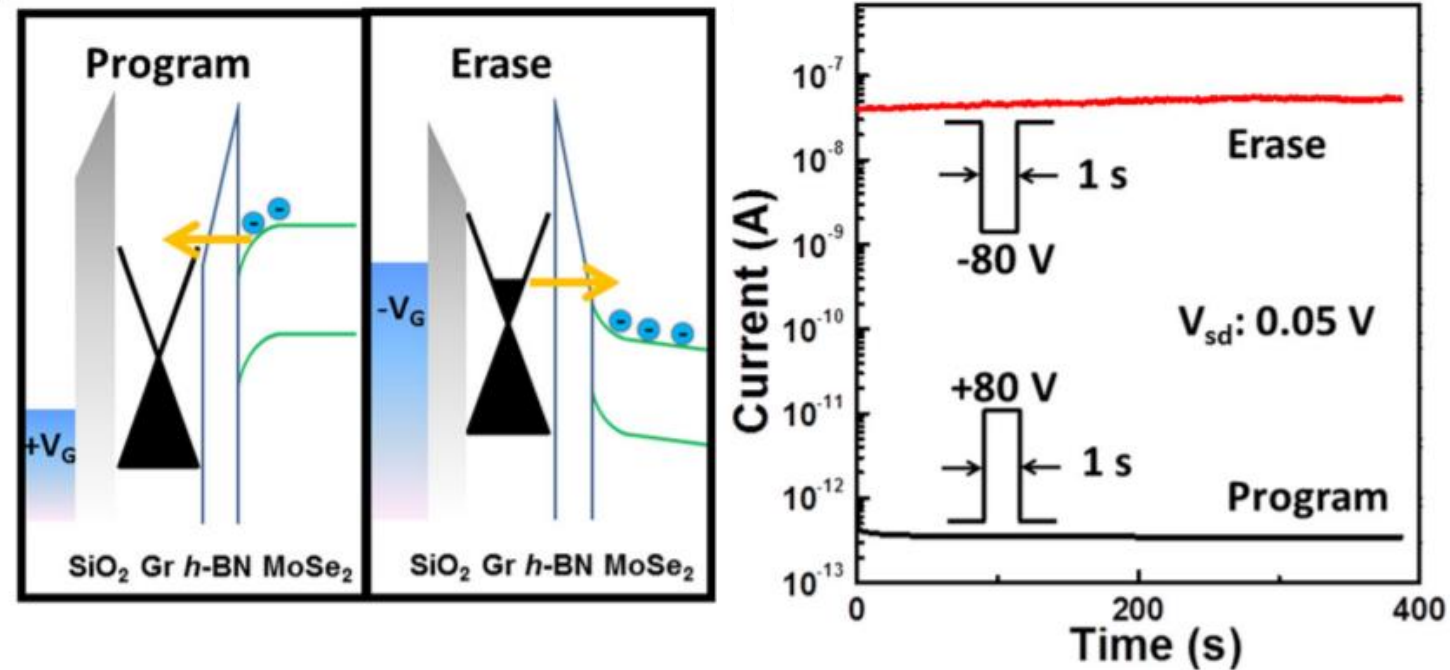
Gate-controlled potential difference can induce carrier injection into semiconductors.

Usually this phenomenon is NOT considered doping!

Due to their atomic thickness, TMDs are highly sensitive to electric field and thus some method can ensure a doping-like effect even after withdrawal of the gate bias.

Luo et al., Nanoscale Horiz., 4, (2019)

Floating Gate Modulation



Electrons tunnel in from the graphene contact through the h-BN (the direction depends on the applied gate bias, here named «Erase» and «Program»).

By applying a high V_g for a short time (1s), the channel conductivity changes for a long time.

Cheng et al., Appl. Phys. Lett. 110, (2017)